

Broadcom SiPM AFBR-S4N66P024M (2x10)

one single element

6x6 mm²/each

Total: 0.36 cm²

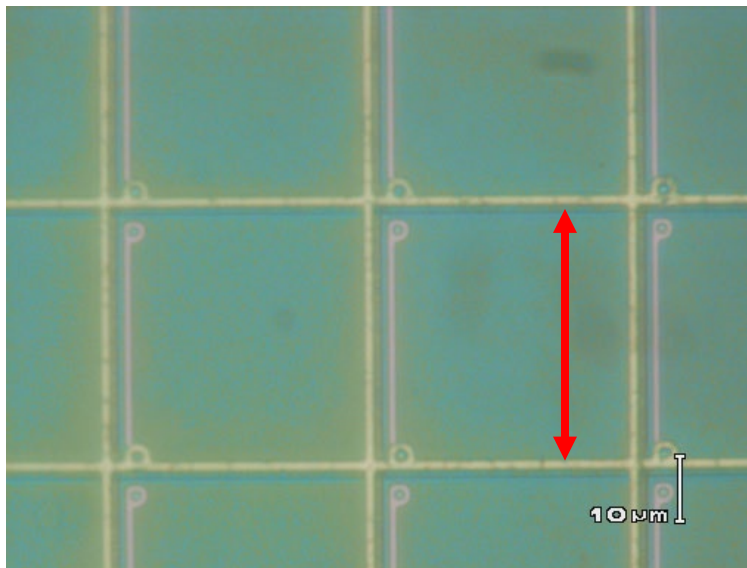
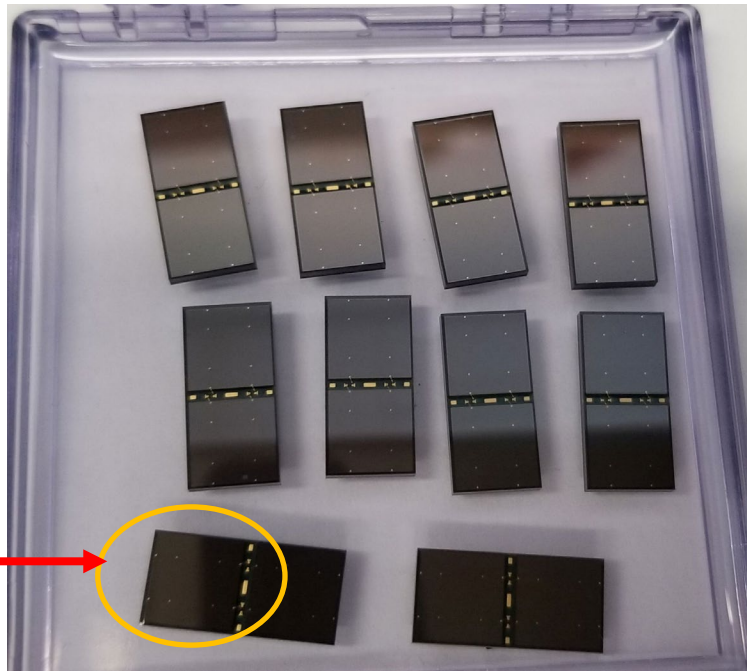
N_{cell}=22428

C _{terminal}	RT	LN ₂
per element	~2.91 nF	~2.98 nF
per cm ²	~8.1 nF/cm ²	~8.3 nF/cm ²

C_{terminal} slightly larger in cold !

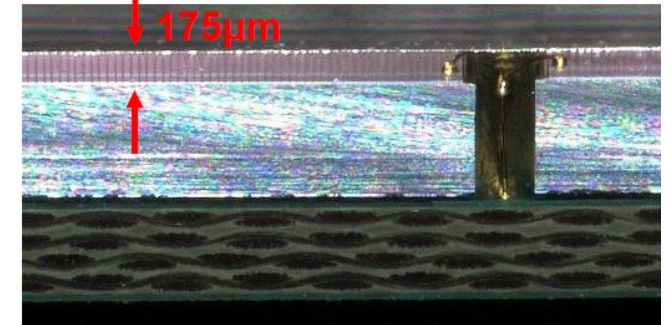
when connected in 8P2S

C_{terminal} ~ 12 nF (5.76 cm²)



epoxy resin window: 175 μm thick

Side View



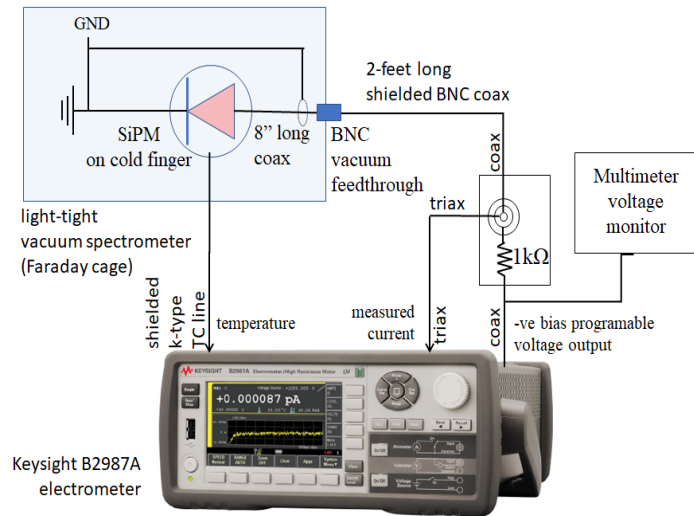
 BROADCOM™

Claudio Piemonte 2023 IEEE

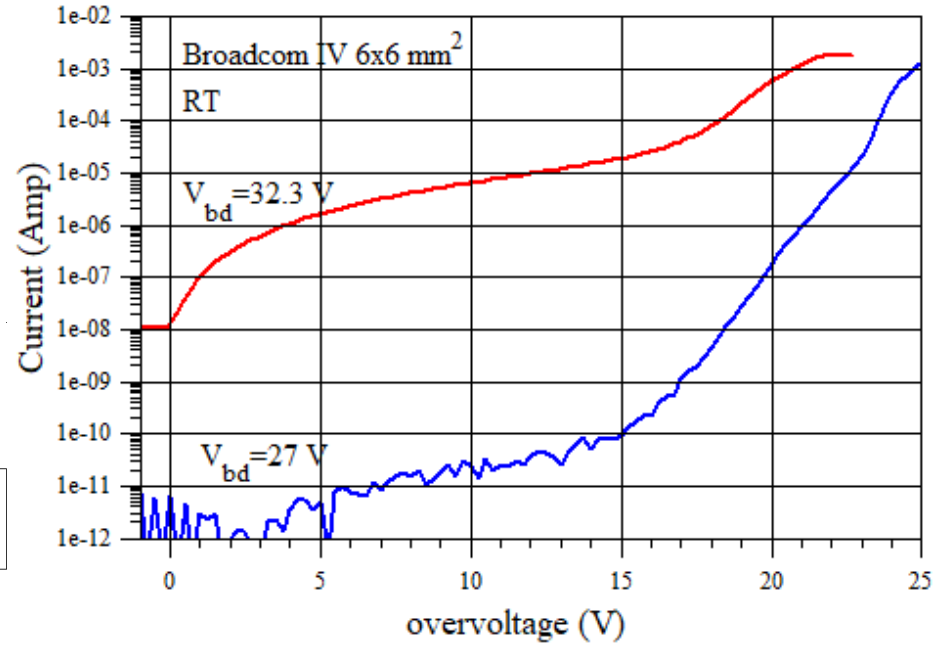
pixel size: 40 μm

IV measurement

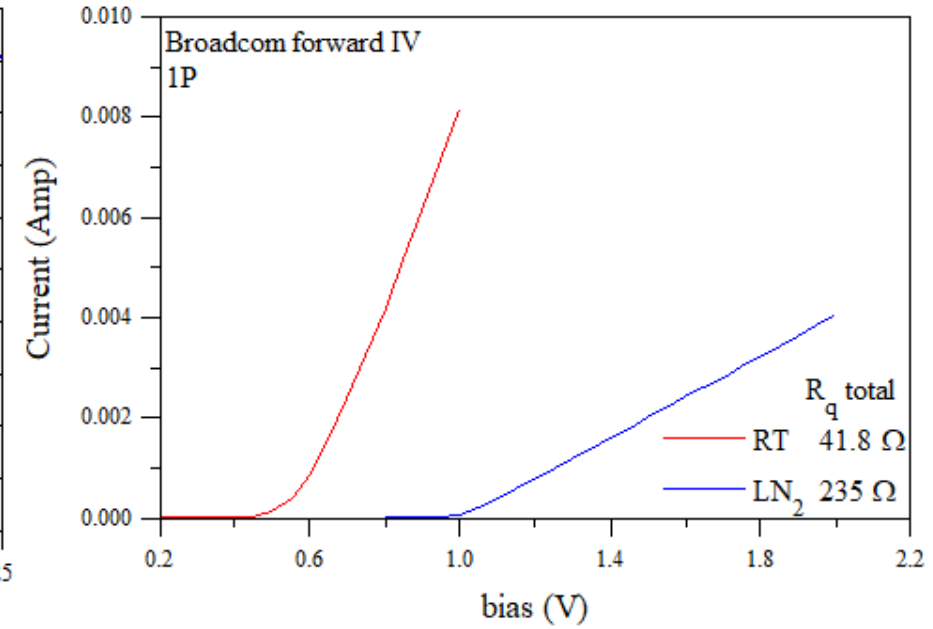
Broadcom 6x6 mm²



reverse IV



R_{quench} : forward IV

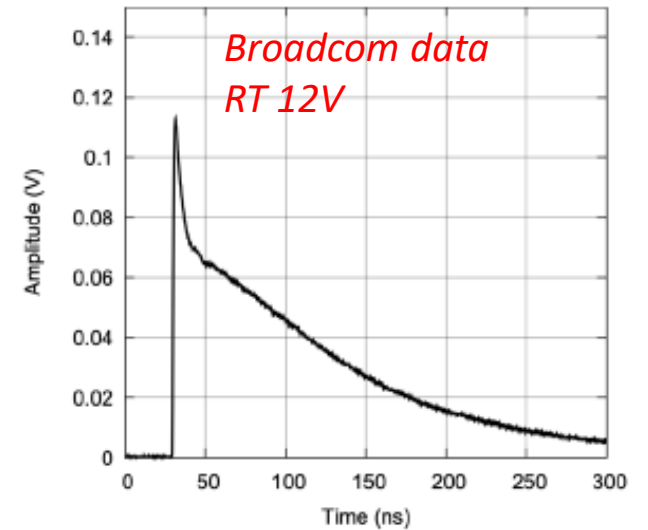
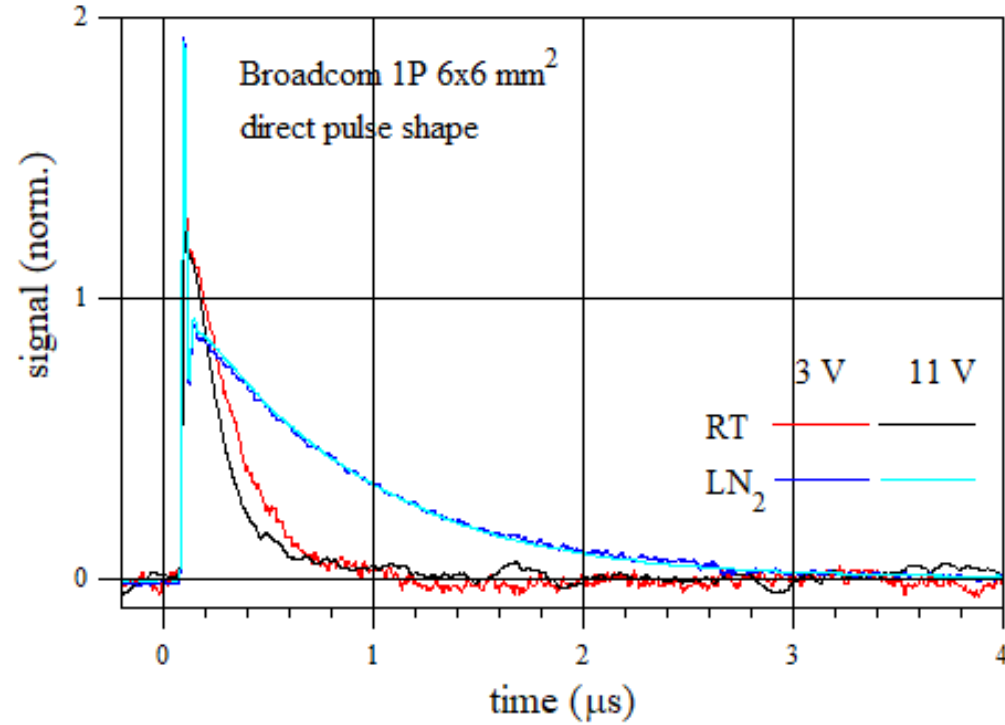
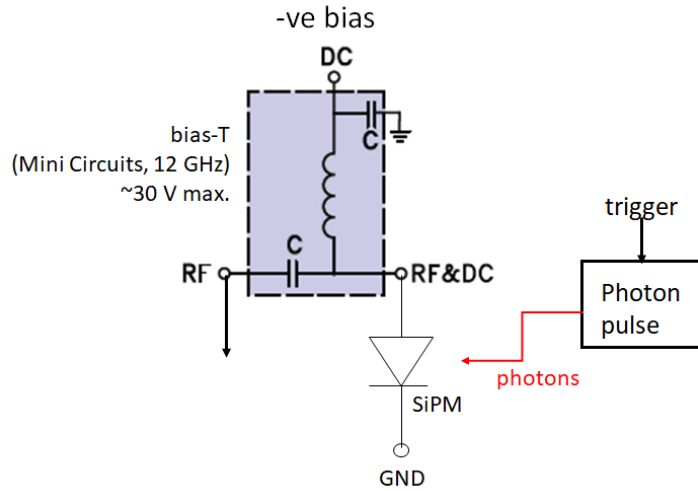


Broadcom 6x6 mm ²	RT	LN ₂
$V_{breakdown}$	32.3 V	27 V
R_{quench}	41.8 Ω	235 Ω

R_{quench} is larger in LN₂ (3 μ s shaper is used)

Direct pulse shape: 1-pe

Broadcom 6x6 mm²

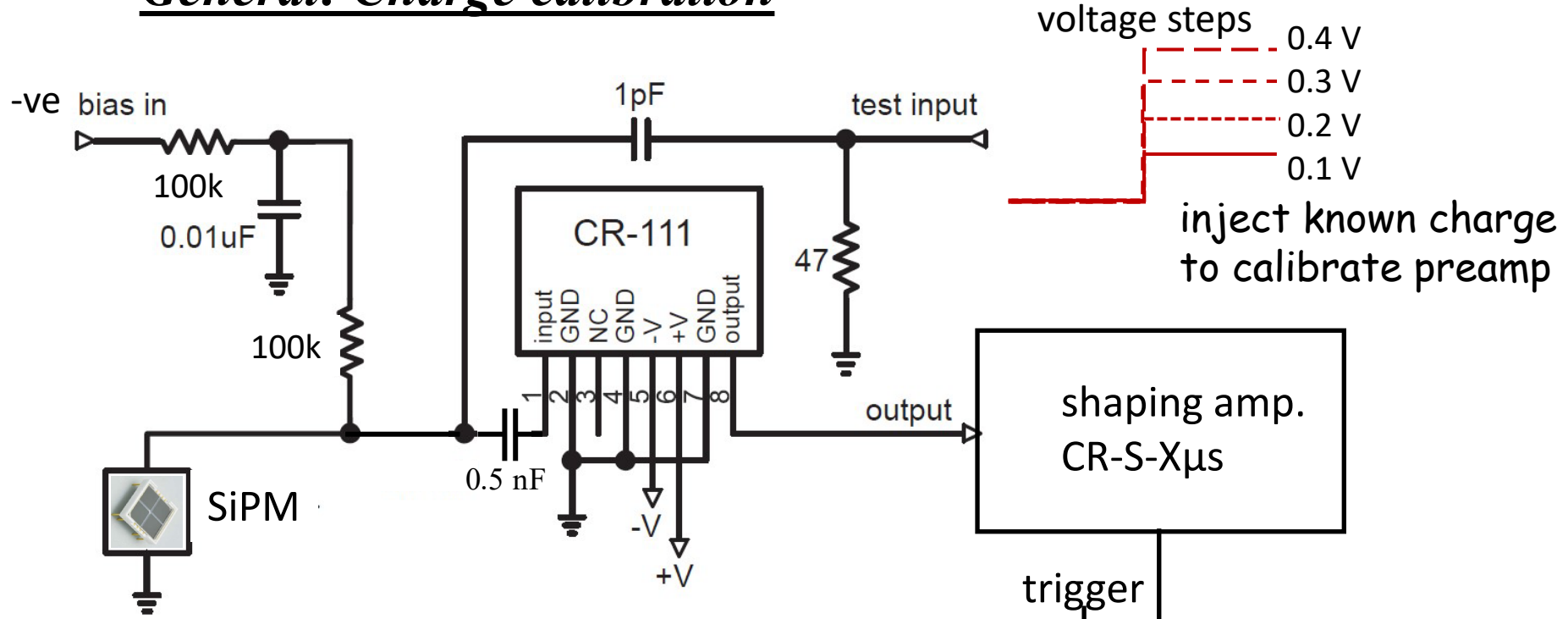


photoelectron charge = $\int V dt$, incomplete charge collection if not fully integrated

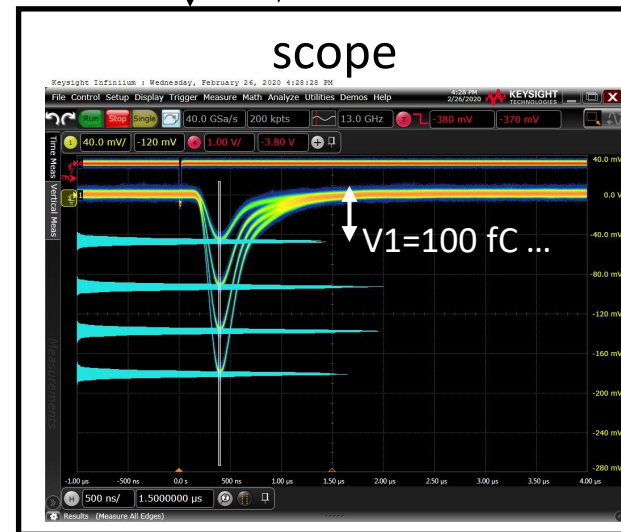
RT: fall time shorter at higher OV

LN₂: fall time independent of OV

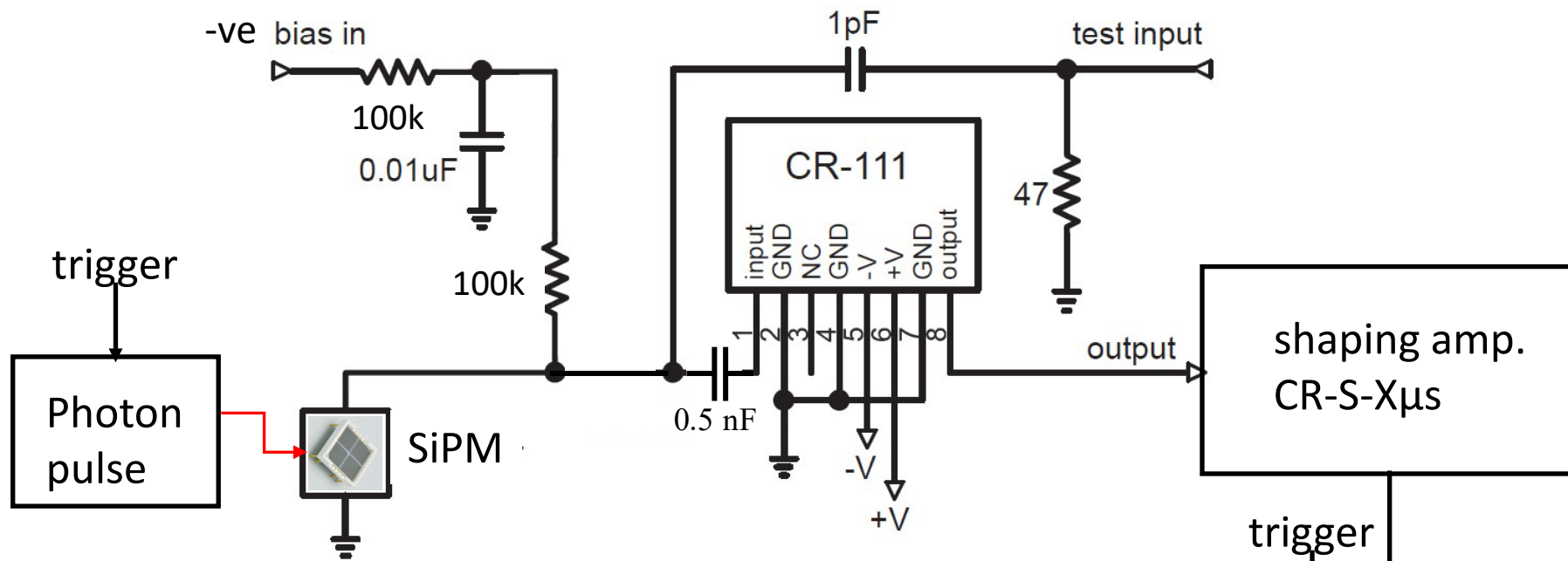
General: Charge calibration



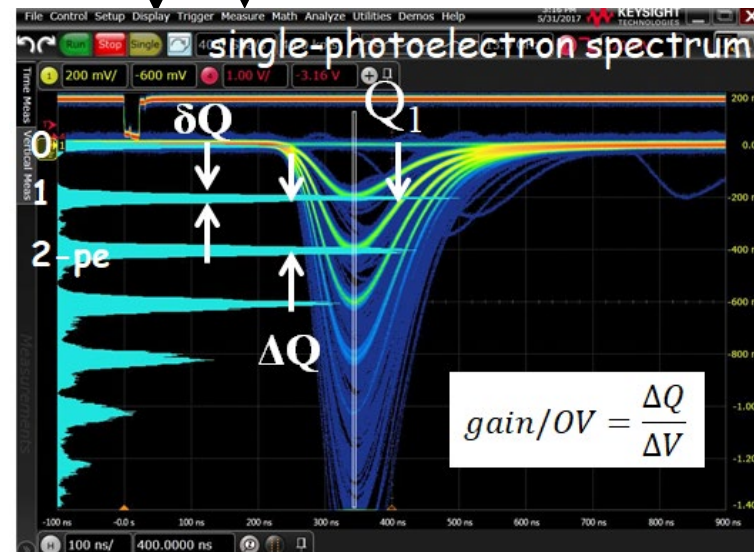
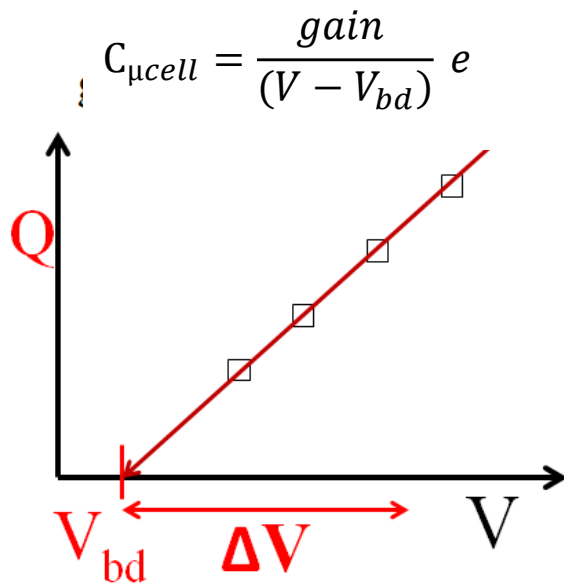
SiPM connected and biased



General: SiPM charge gain measurement – (zero charge gain method)



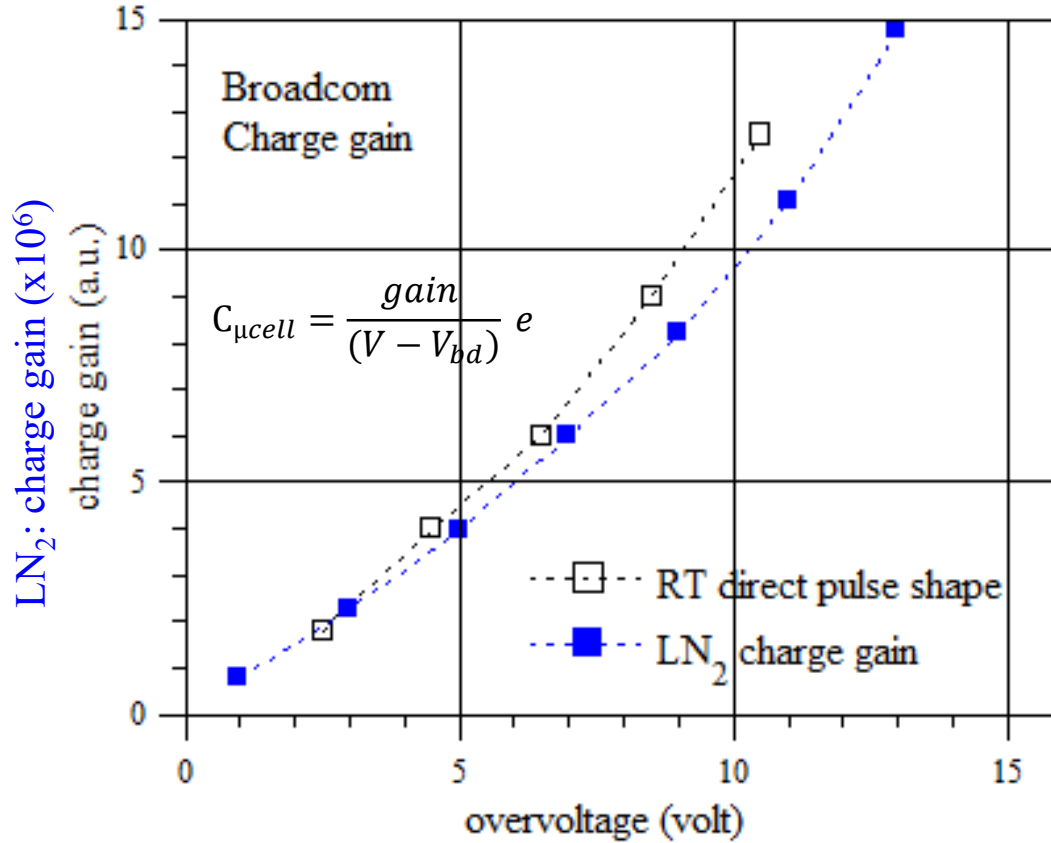
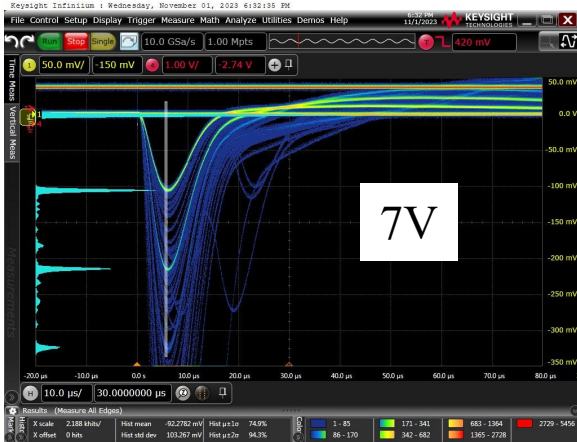
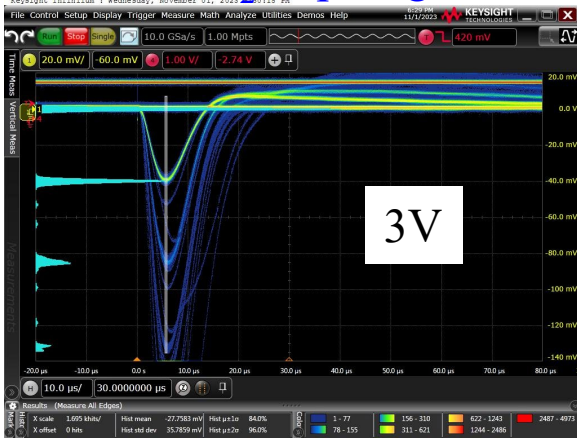
- gain measured from well resolved photoelectron peaks
- breakdown voltage linearly extrapolated



1-pe charge gain

Broadcom 6x6 mm²

LN₂: 1-pe signal

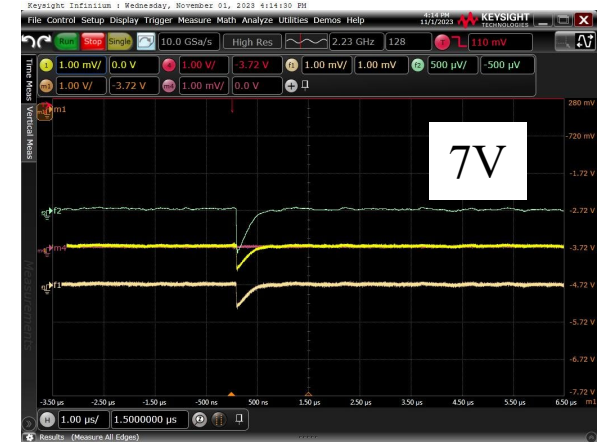
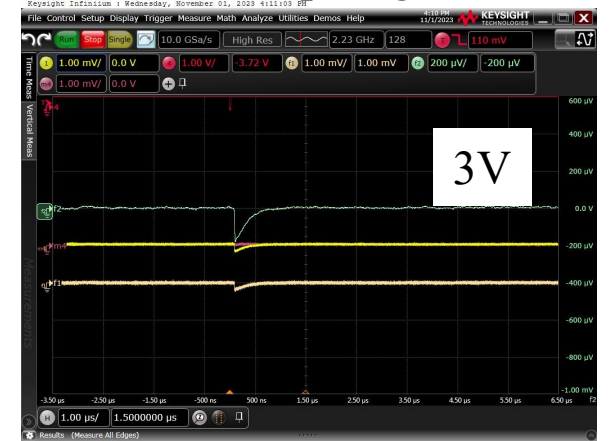


~0.77 x10⁶/OV at 5V

~128 fF/μcell @ 5V (~2.8 nF per element)

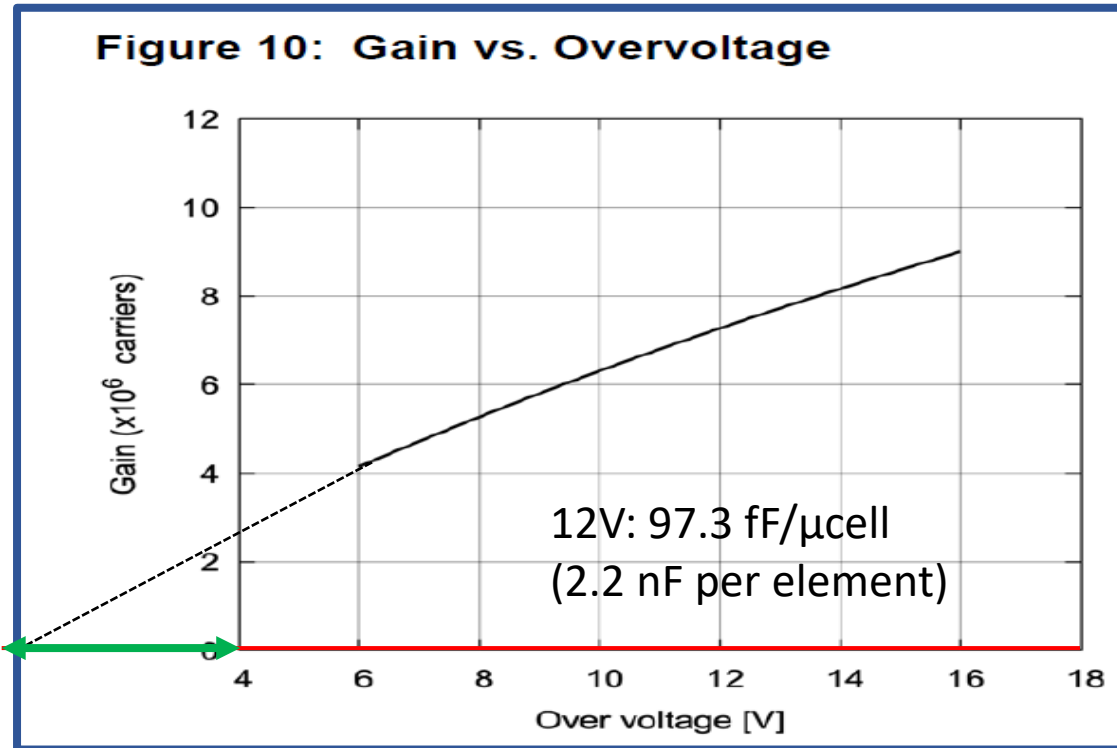
charge gain appears slightly nonlinear

RT: n-pe signal



Broadcom 1-pe gain data (room temperature)

doesn't appear to cross at 0V



doesn't appear to cross at 0V

CT, correlated noise, DCR, PDE ...

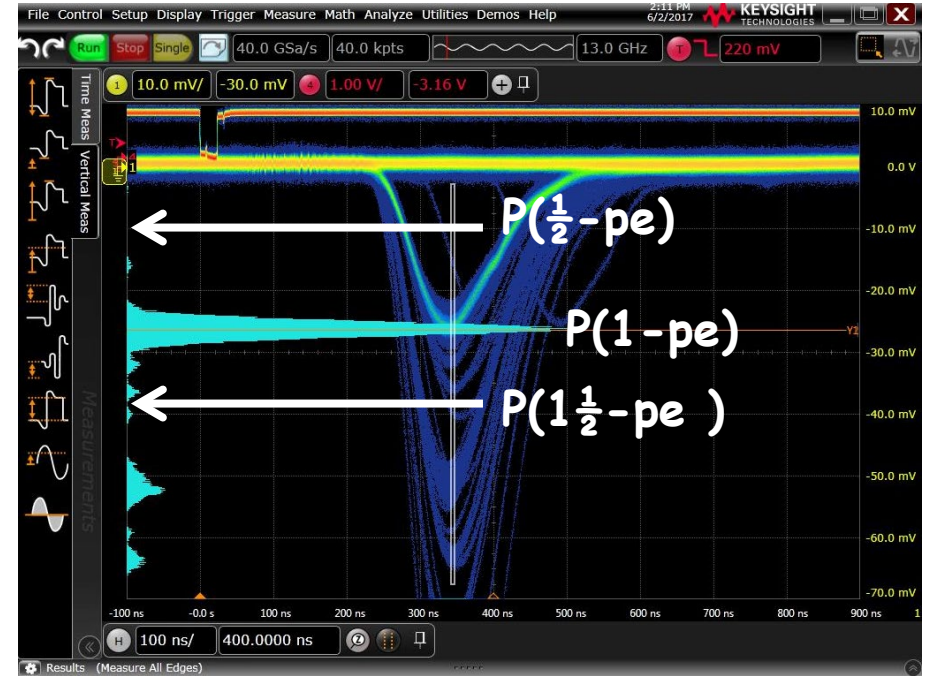
1. Charge gain and correlated noise are determined from single-photon pulse measurements by attenuating a 50kHz repetition rate 405 nm photon source to <0.04 photons/pulse.
2. Correlated noise factor CT & AP, are determined from count rate $P(1\frac{1}{2}\text{-pe})/P(\frac{1}{2}\text{-pe})$ and $P(\frac{1}{2}\text{-pe, delayed with 1 to 10 } \mu\text{s gate window})/P(\frac{1}{2}\text{-pe})$, respectively.
3. PDE is obtained by fitting a Poisson distribution to the photoelectron spectrum, against the incidence # of photons.

General: time-correlated crosstalk (CT)

SR400 time-gated photon counter (gate width 50 ns)

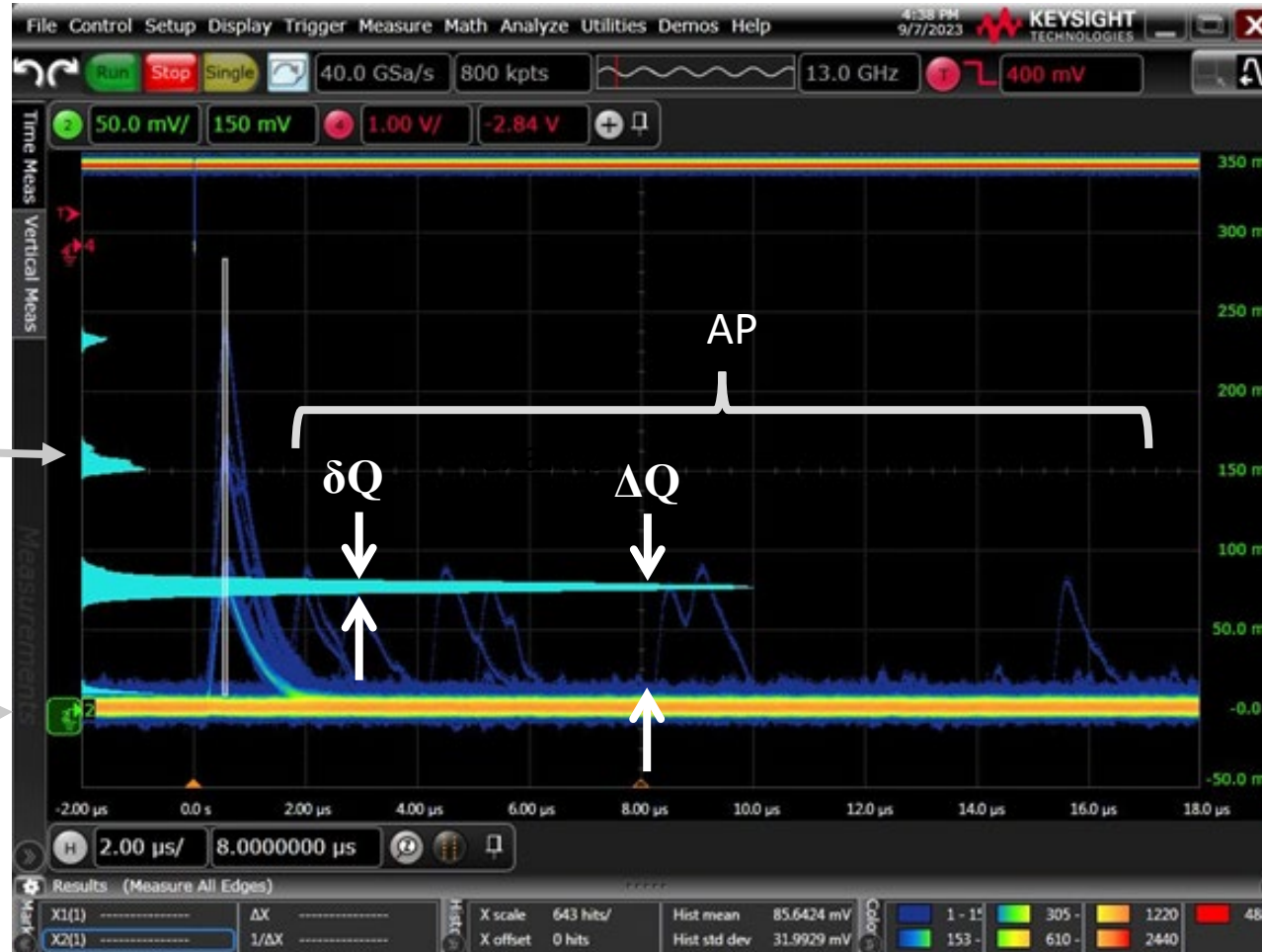
Attenuate to $\ll 1$ -photon/pulse
Determine 1-pe signal level
Measure count rate at $\frac{1}{2}$ -pe & $1\frac{1}{2}$ -pe levels

$$\text{crosstalk} = \frac{\text{count rate } \frac{3}{2}\text{-pe}}{\text{count rate } \frac{1}{2}\text{-pe}}$$



General: time-correlated afterpulse (AP) etc ...

SR400 time-gated photon counter (gate width 1 to 18 μs)



$$CT = \frac{P(1\frac{1}{2}\text{-pe})}{P(\frac{1}{2}\text{-pe})}$$

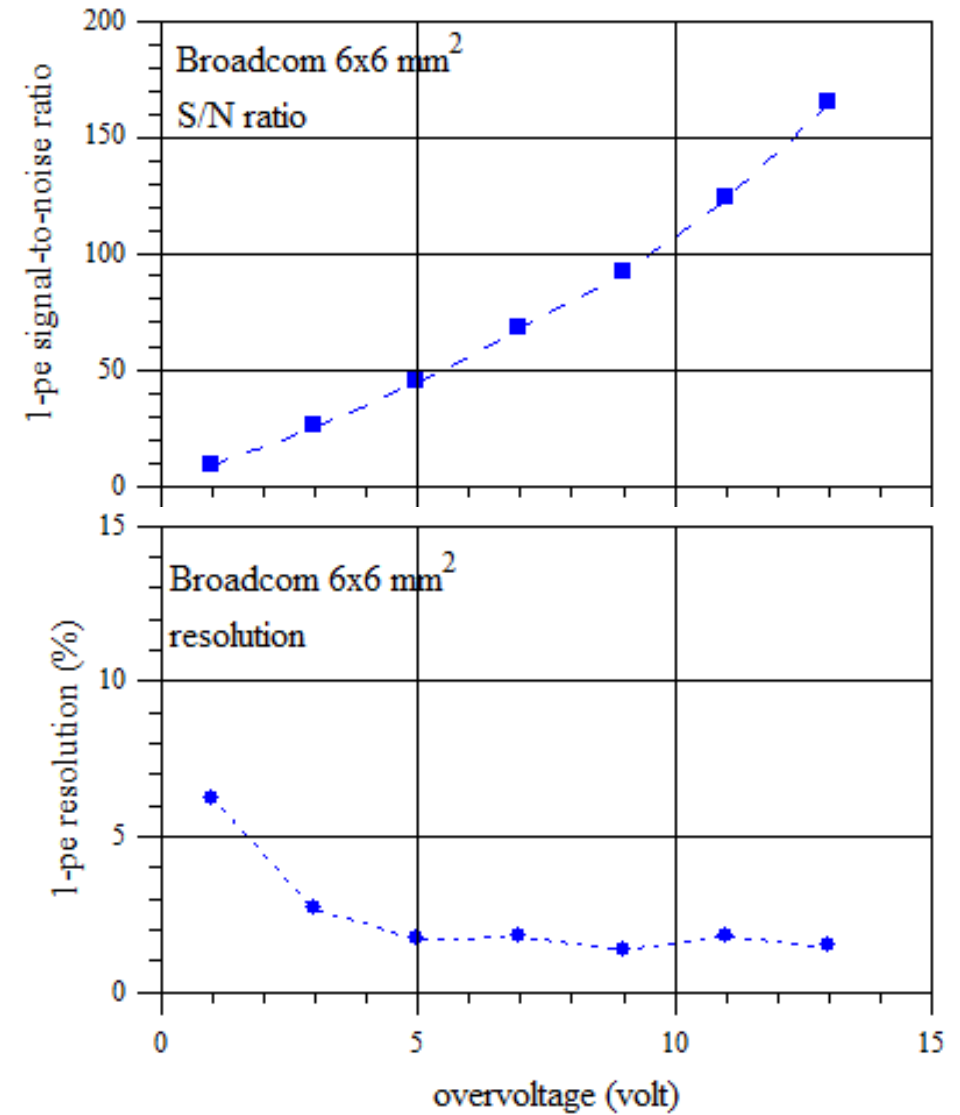
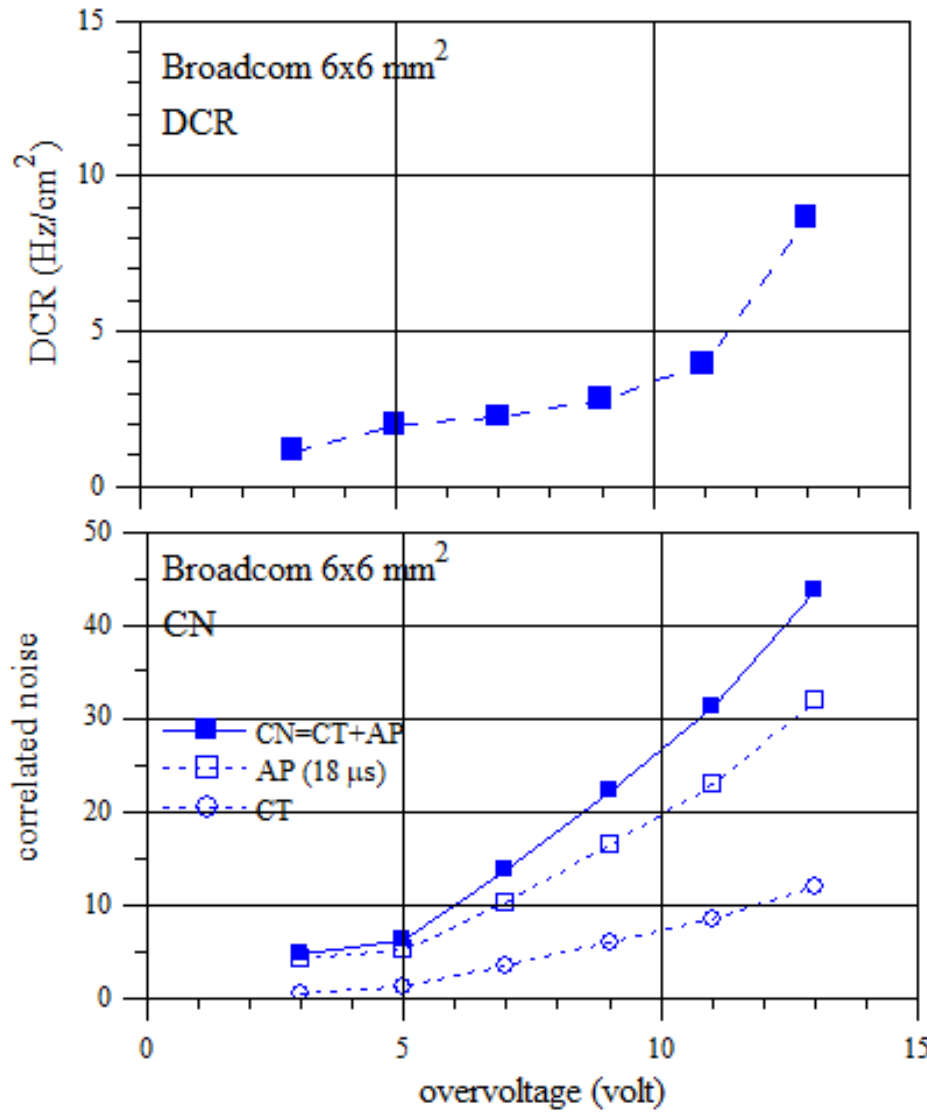
P(0): electronic noise
 $\delta P(0) \sim 14 \text{ fC}$

$$S/N = \frac{\Delta Q}{\delta P(0)}$$

$$1\text{pe resolution} = \frac{\delta Q}{\Delta Q}$$

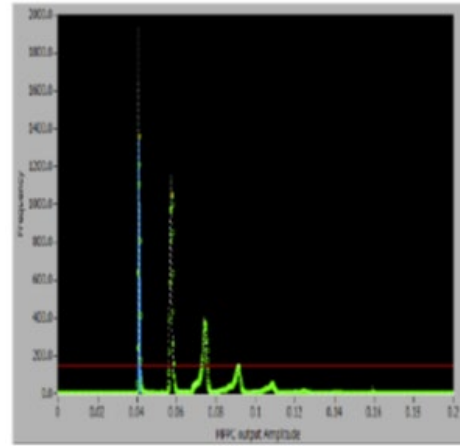
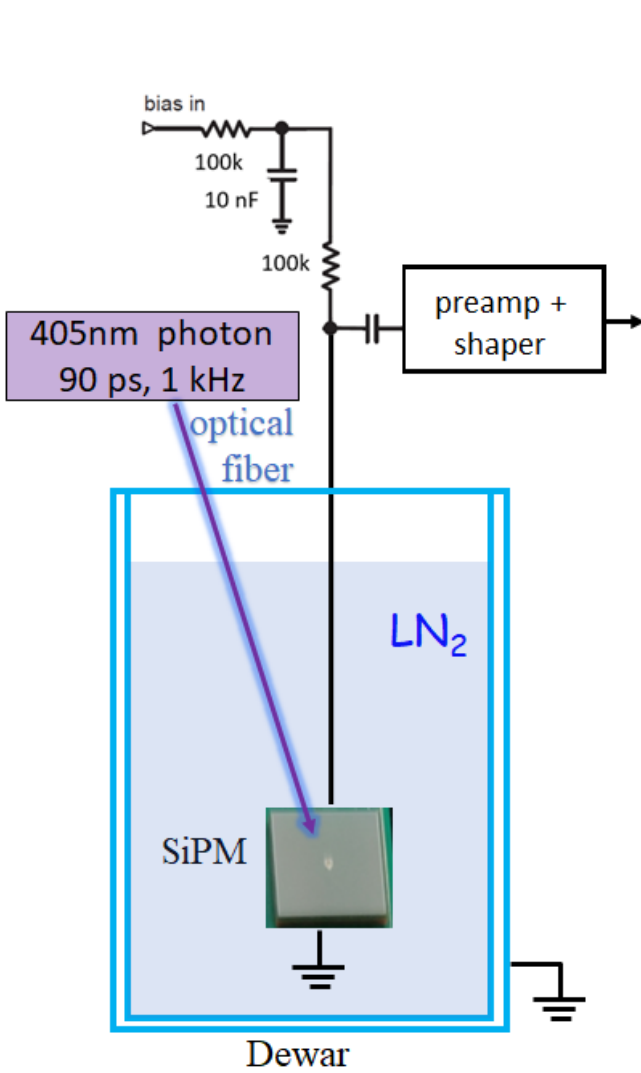
$$AP = \frac{\text{count rate } [P(\frac{1}{2}\text{-pe, delayed gate } \Delta T [\sim 1 \text{ to } 18 \mu\text{s}])]}{1\text{pe count rate } [P(\frac{1}{2}\text{-pe})]}$$

Broadcom 6x6 mm²
LN₂:1-pe signal



- DCR & 1-pe resolution are sufficiently low
- CN < 15%, S/N ~70 below 7V,

PDE is calculated by fitting a Poisson distribution to the photoelectron spectrum



$$P(n, x) = \frac{n^x e^{-n}}{x!}$$

$$P(n, 0) = \frac{\left(\frac{N_{ped}}{N_{tot}}\right)}{\left(\frac{N_{ped}^{dark}}{N_{tot}^{dark}}\right)} \quad (\leftarrow \text{dark pulse correction})$$

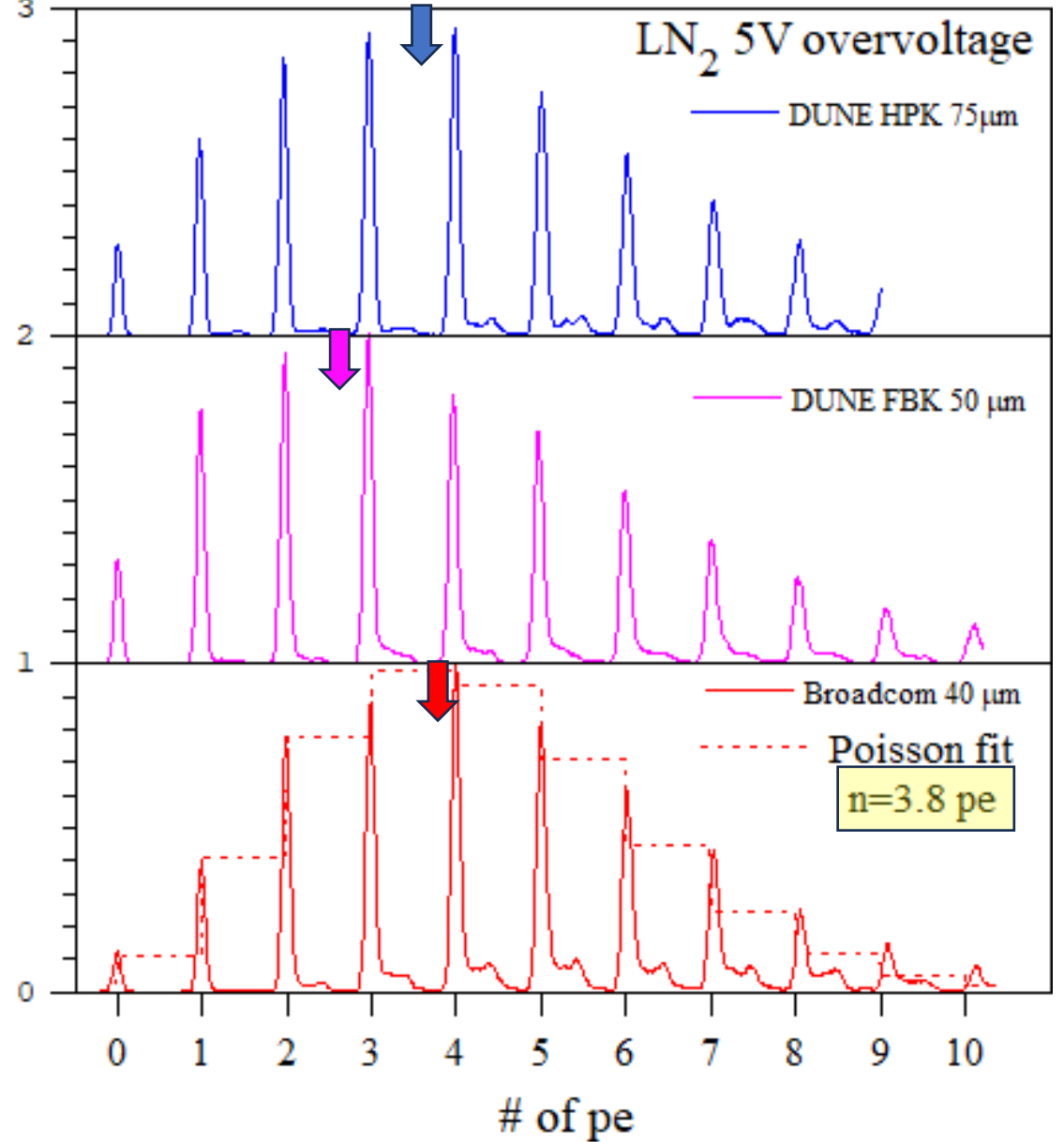
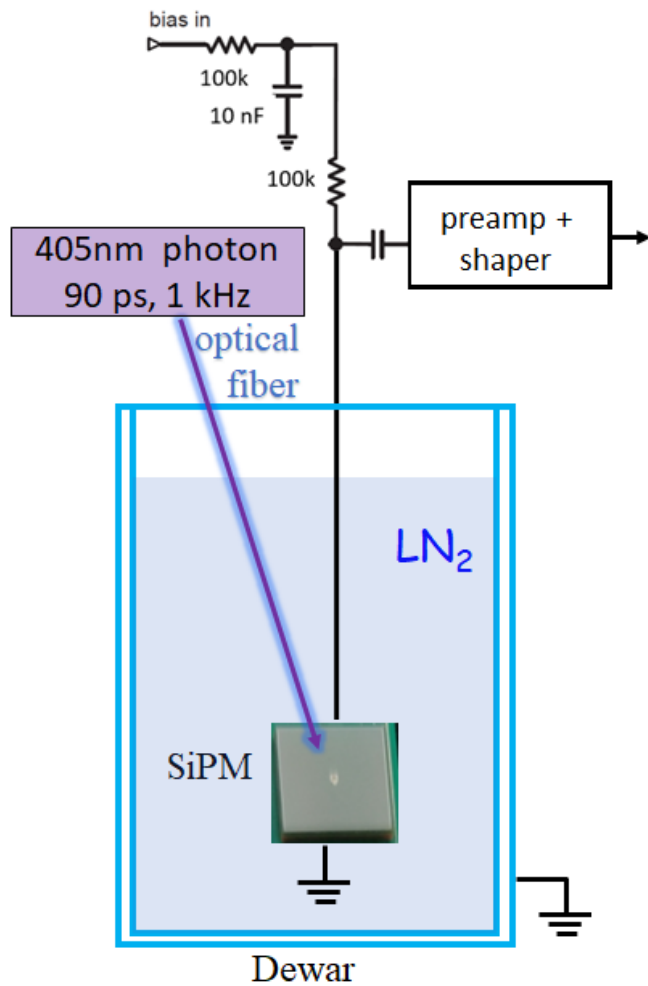
$$\rightarrow n = -\ln\left(\frac{\frac{N_{ped}}{N_{tot}}}{\frac{N_{ped}^{dark}}{N_{tot}^{dark}}}\right) = -\ln\left(\frac{N_{ped}}{N_{tot}}\right) + \ln\left(\frac{N_{ped}^{dark}}{N_{tot}^{dark}}\right)$$

n : average number of photons detected by MPPC
 x : number of photons detected by MPPC

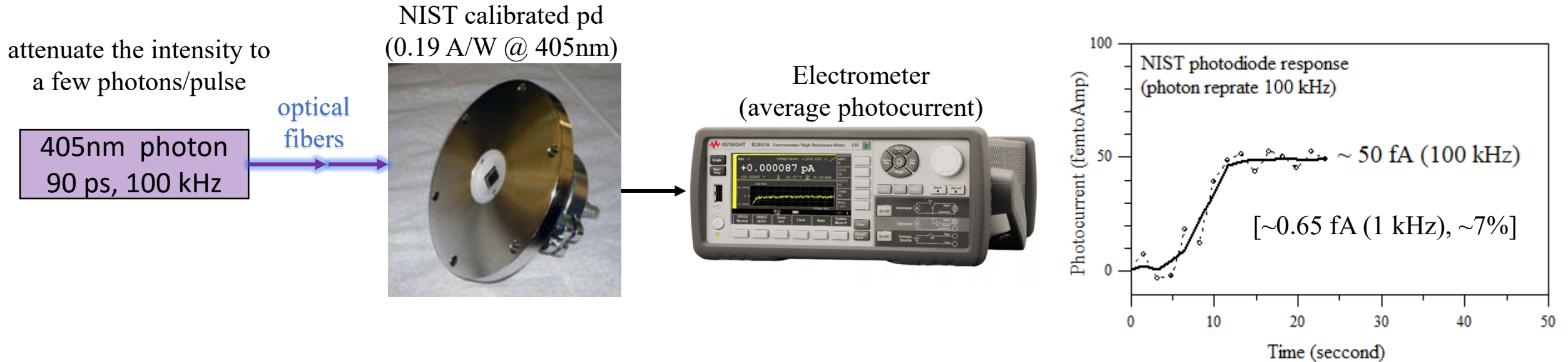
N_{ped} : number of events at 0 p.e. during pulsed light measurement
 N_{tot} : number of all events during pulsed light measurement
 N_{ped}^{dark} : number of events at 0 p.e. in dark state
 N_{tot}^{dark} : number of all events in dark state

n = Poisson fitted mean number of photoelectrons

relative PDE in LN₂ (Broadcom, DUNE FBK, DUNE HPK)



Number of incidence photons is determined from the measured photocurrent at the selected wavelength from a NIST calibrated photodiode



$$\# \text{ of } 405 \text{ nm photons} = \frac{0.65 \text{ fA}}{(1 \text{ kHz}) \left(0.19 \frac{\text{A}}{\text{W}}\right) (1.6 \times 10^{-19} \text{ J/eV}) (3.06 \text{ eV})} (0.86) = 6.01 \text{ photons/pulse}$$

PDE in LN₂ (Broadcom, DUNE FBK, DUNE HPK)

$$\text{PDE} = \frac{\# \text{ pe}}{\# \text{ hv}} = F_{\text{geometry}} \times \text{QE}_{e-p}(\lambda, T) \times \varepsilon_{\text{avalanche}}(\Delta V, \lambda, T)$$

↑
geometric
↑
photon
↑
photoelectron

$$\text{PDE (Broadcom, 405 nm, 5V, LN}_2) = \frac{\# \text{ photoelectrons out}}{\# \text{ photons in}} = \frac{3.8}{6.01} = 0.63$$

PDE @ 405 nm 5V OV in LN2	Poisson fitted n-pe	absolute PDE (±7%)	Spec. RT
DUNE HPK 75 μm	3.15	0.52	~0.47
DUNE FBK 50 μm	2.93	0.48	n/c
Broadcom 40 μm	3.8	0.63	~0.62

event burst phenomenon

recent observation of event burst phenomenon: *DUNE & DarkSide*

Results: burst discovery

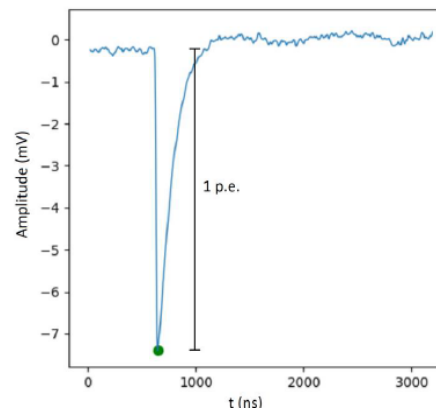
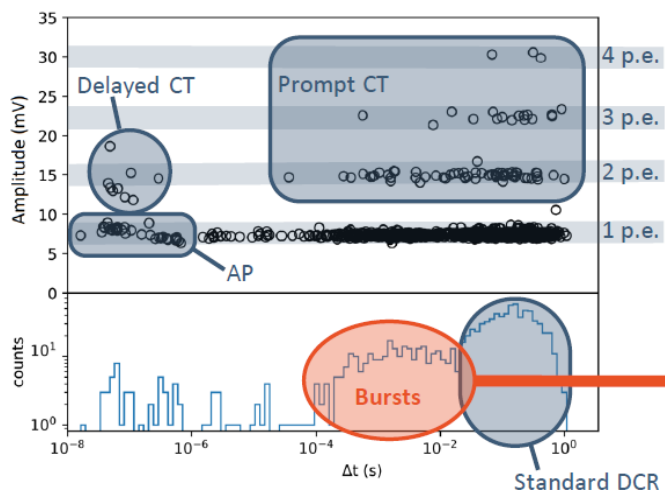
Custom **offline analysis** to extrapolate DCR, CT and AP values in two steps:

Event isolation

- Peak signals identification
- Extract amplitudes and relative times

DCR analysis

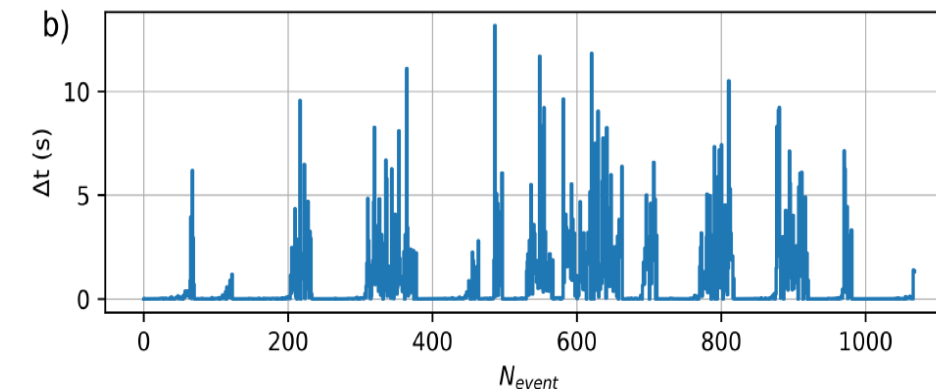
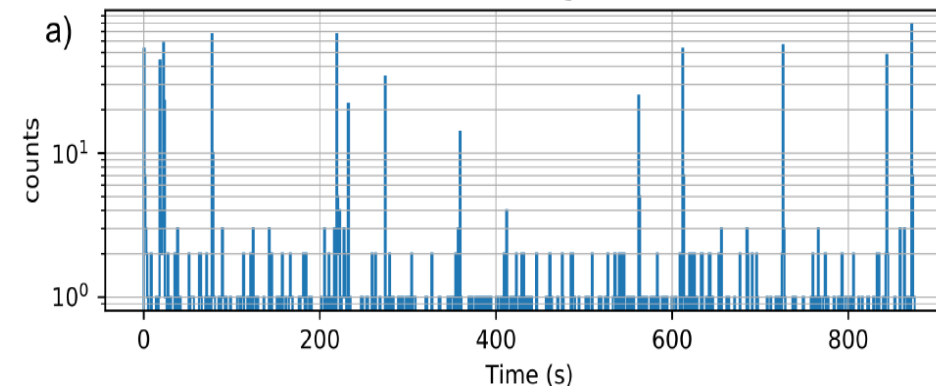
- Calculates DCR, AP and CT by counting events




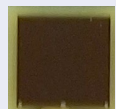

Quick trains of correlated events

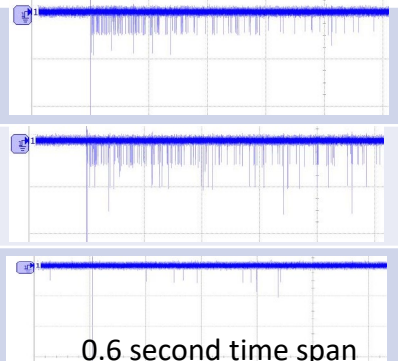
Currently under investigations...

HPK 13360-6075LRQ - OV= 3V

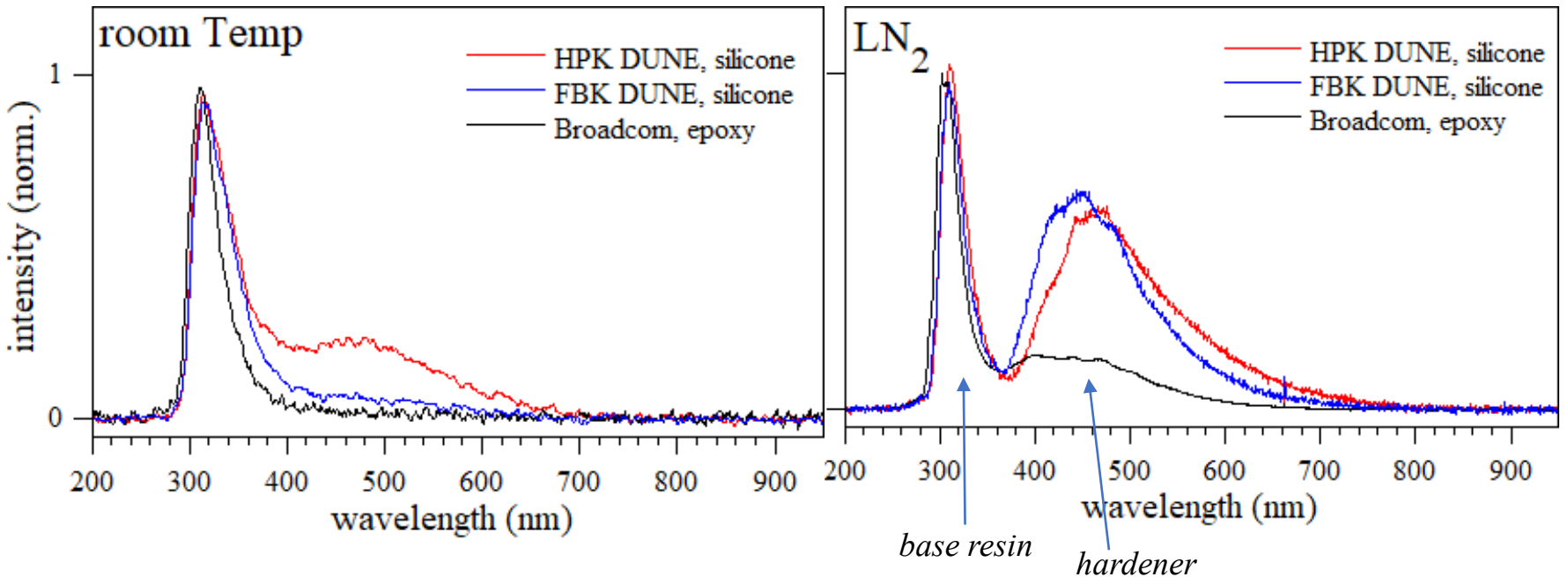
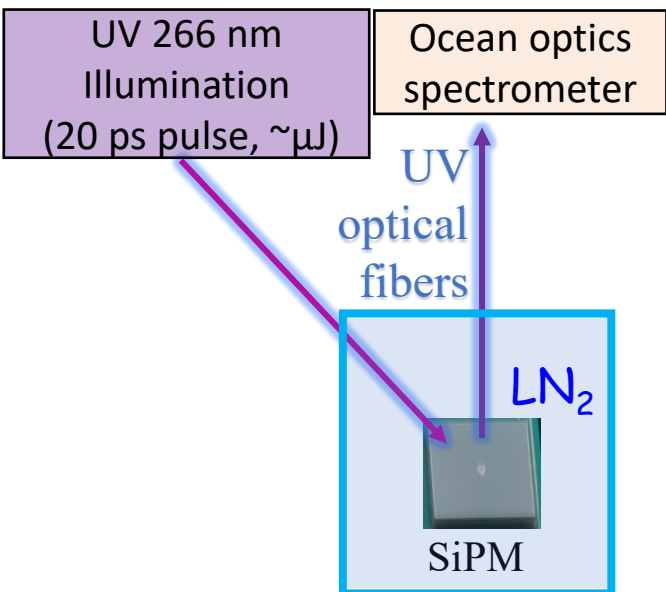


event burst phenomenon observed at BNL (SiPMs in LN₂ in completed darkness) *LIDINE2022*

#	Vendor & Model	device	pixel	substrate	connect.	window	spectral resp.	Burst, events/30 minutes
1	HPK S13360-HS-HRQ (DUNE)		75 μm	PCB	hole wire bond	silicone resin, 150 μm	280 - 900 nm	Yes, 5
2	FBK triple trench (DUNE)		50 μm	PCB	wire bond	silicone resin, xx μm	~300 to 900 nm	Yes, 10
3	Broadcom		40 μm	PCB	wire bond	epoxy resin 175 μm	~300 to 900 nm	No or low



photoluminescence of SiPMs at room temperature and in liquid nitrogen.



Broadcom SiPM

PROs:

- PDE is slightly higher than DUNE FBK or DUNE HPK
- No event burst is observed – no afterglow

CONs:

- DCR in LN₂ is slightly higher but well manageable
- Correlated noise (CT & AP) is slightly higher
- Charge gain appears nonlinear with overvoltage
- Terminal capacitance is high at room or in LN₂

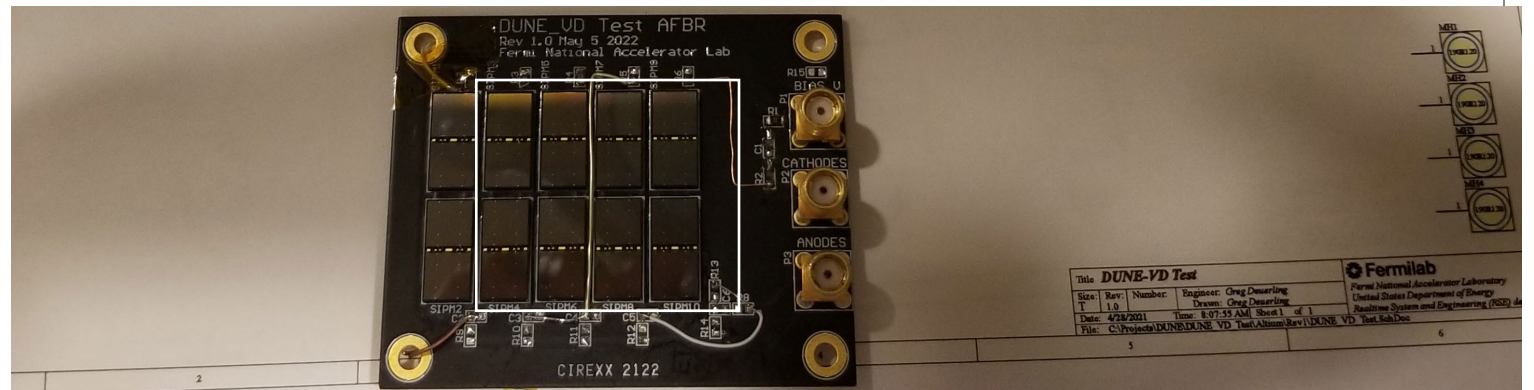
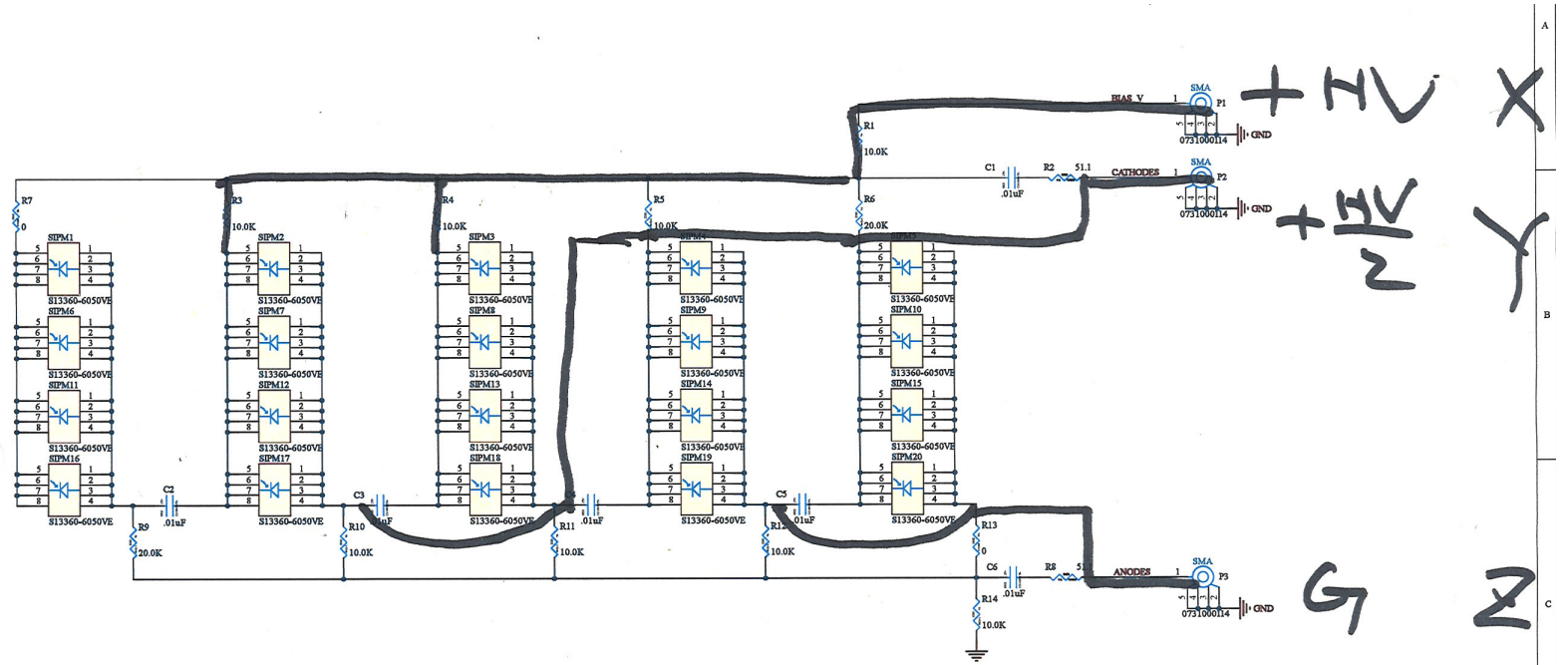
Readout of Broadcom 4x4 SiPM
connected in 8P2S (5.76 cm²)

Broadcom 4x4 SiPM connected in 8P2S (5.76 cm²)

8P2S: 16 SiPMs
 6x6 mm²/each
 Total: 5.76 cm²

C _{terminal}	RT	LN ₂
total	~11.4 nF	~12.8 nF

C_{terminal} larger in cold

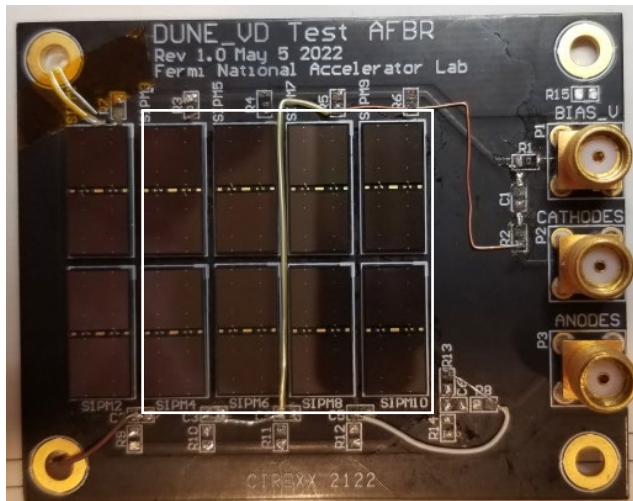


Title: **DUNE-VD Test**
 Size: Rev: Number: Engineer: Greg Deserling
 T: 1.0 Design: Greg Deserling
 Date: 4/28/2021 Time: 8:07:55 AM Sheet: 1 of 1
 File: C:\Projects\DUNE\VD Test\Album\Rev1\DUNE_VD_Test_Kit.doc

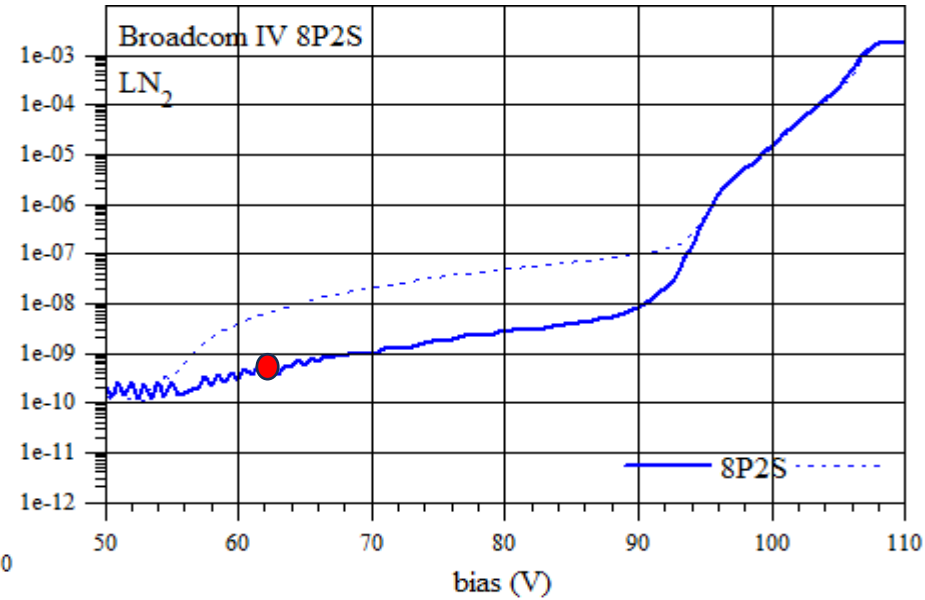
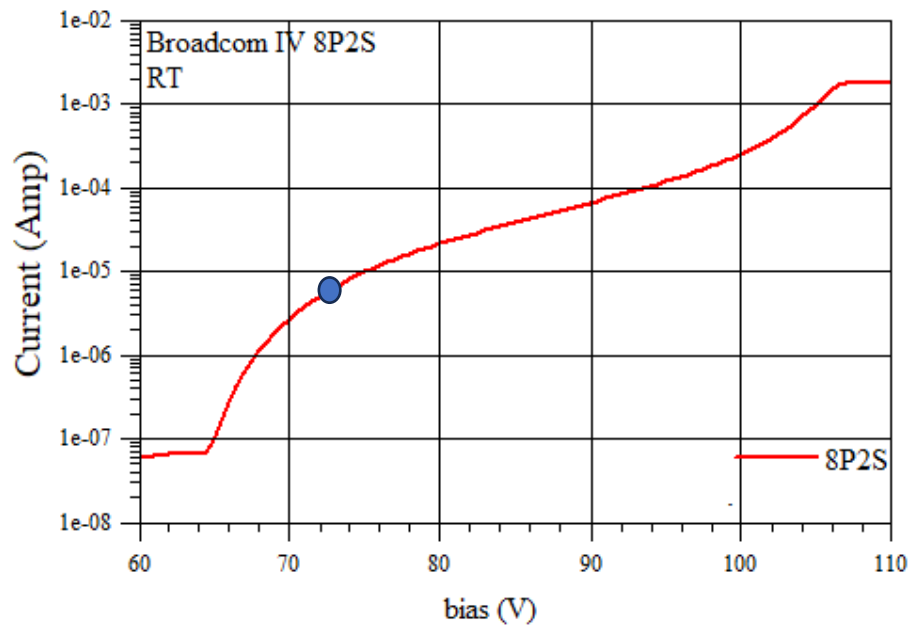
Fermilab
 Fermi National Accelerator Laboratory
 United States Department of Energy
 Radiation System and Engineering (RSE)

Broadcom AFBR-S4N66P024M

~11.4 nF (RT), ~12.8 nF (LN₂)

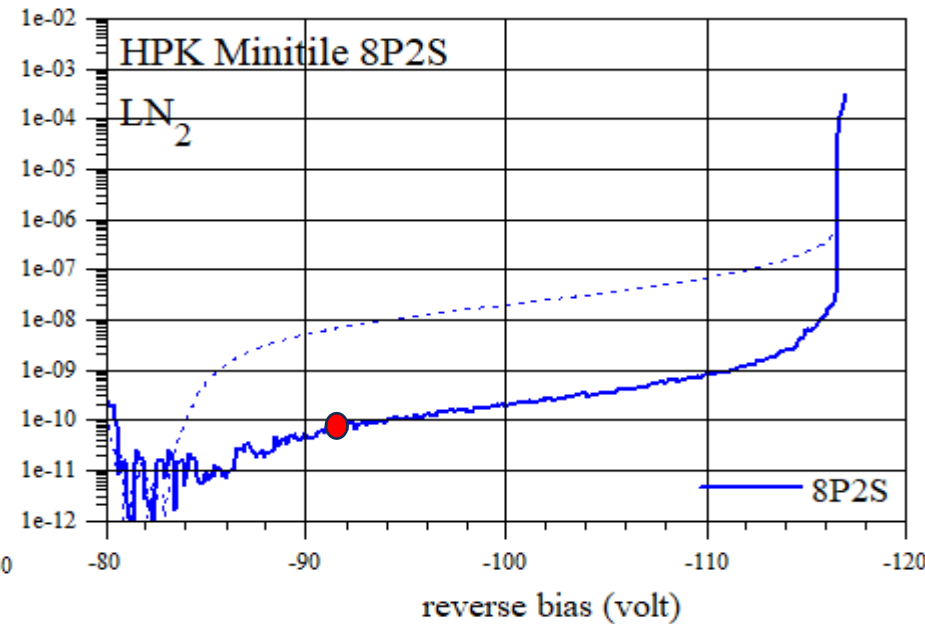
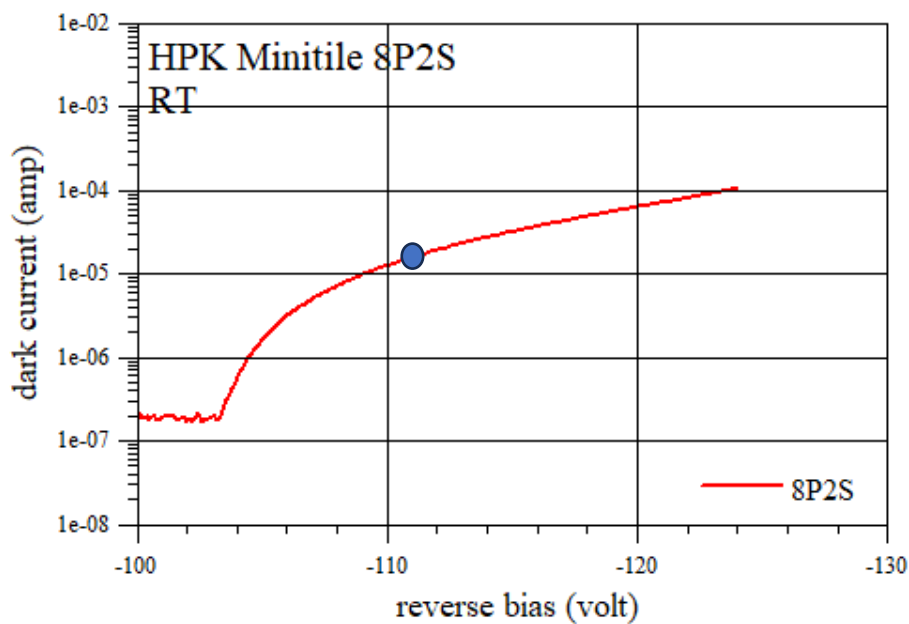
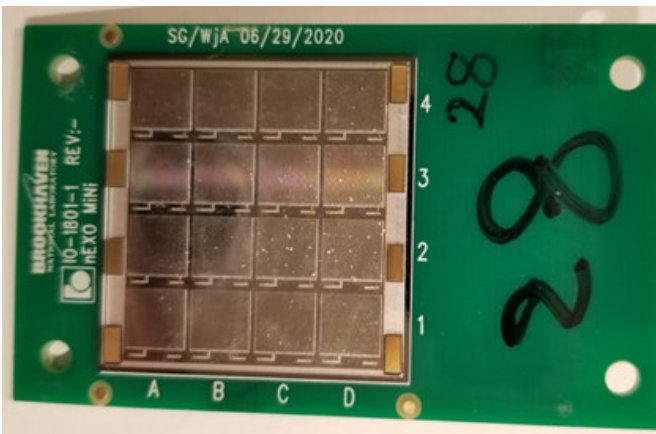


16 SiPMs connected in 8P2S (5.76 cm²)



HPK minitile VUV

~5.8 nF (RT), ~1.9 nF (LN₂)



Broadcom SiPM connected in 8P2S (5.76 cm²)

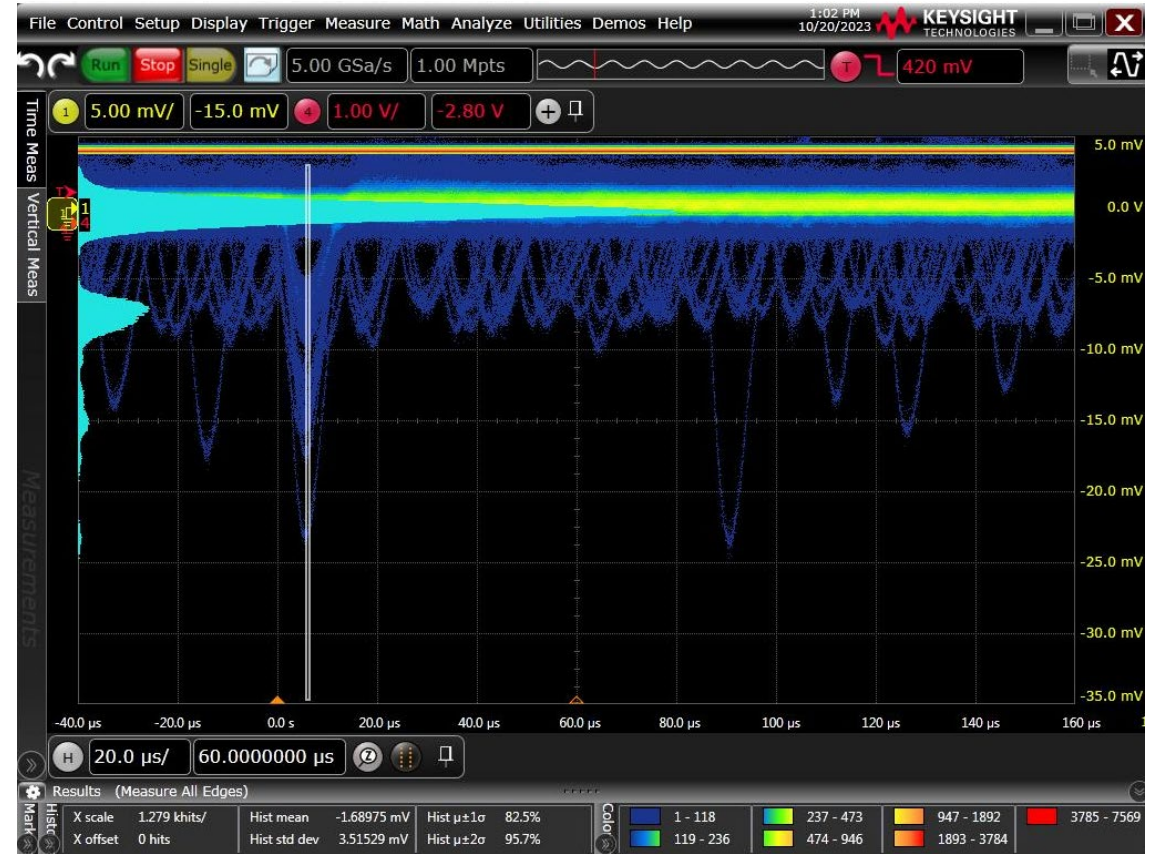
in LN₂ (illumination 90ps 405nm)

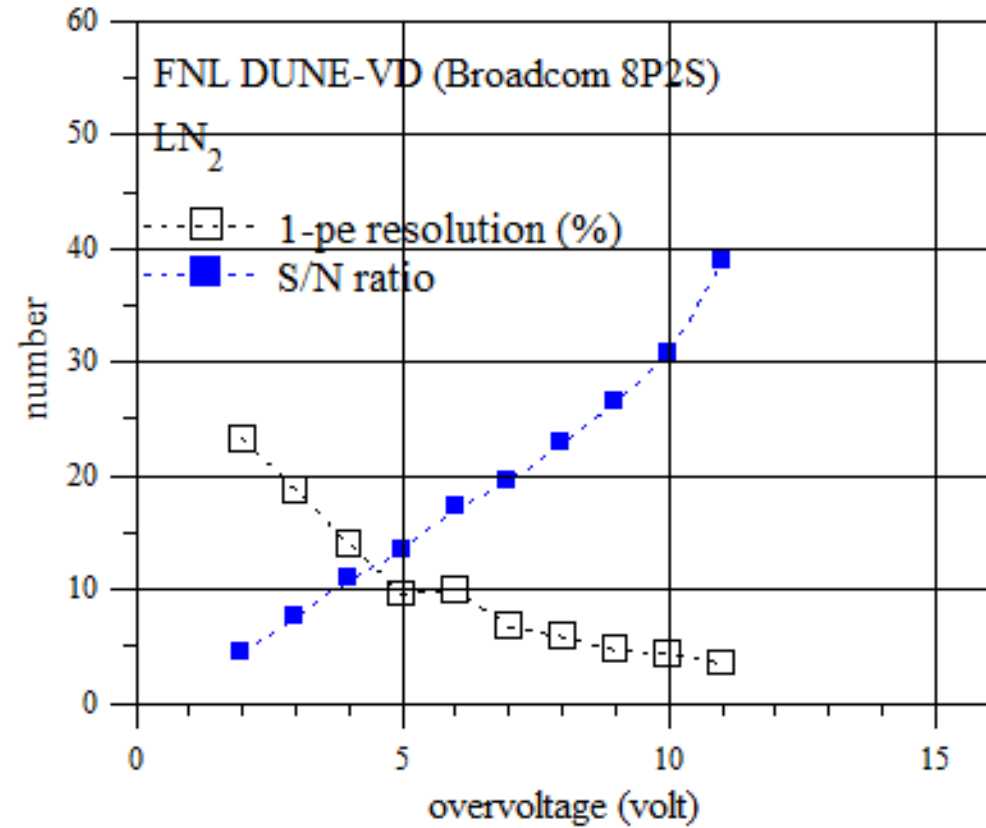
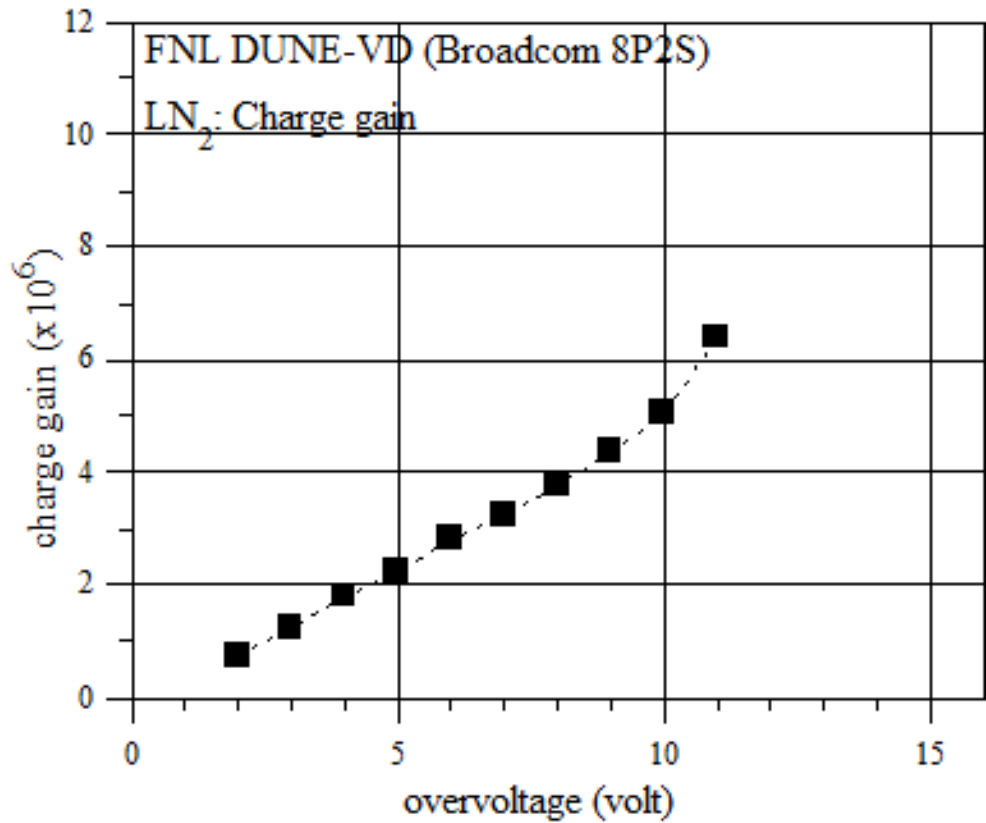
readout of photoelectron pulse: warm preamp+shaper (3 μs)

n-pe detection



1-pe detection





Charge gain $\sim 0.5 \times 10^6 / \text{OV}$

$C_{\text{cell}} \sim 81 \text{ fF}$

$C_{\text{terminal}} \sim 12.8 \text{ nF}$ (5.76 cm², 8P2S)

@ 5V overvoltage

S/N ~ 14

1-pe resolution $\sim 7\%$

LN₂ LArASIC run: Minitiles #27, #28 (8P2S)

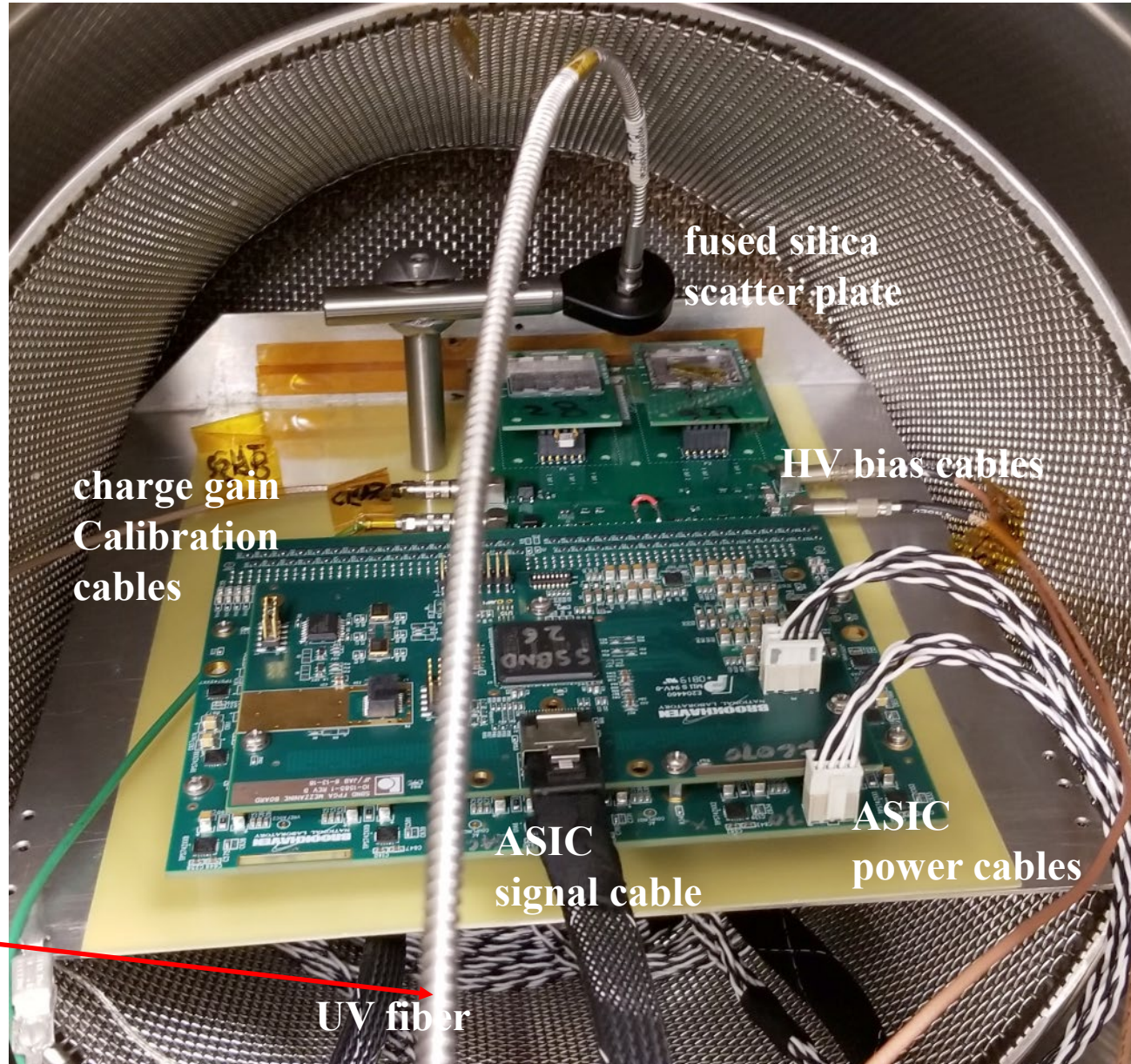
LArASIC

1 μ s peak

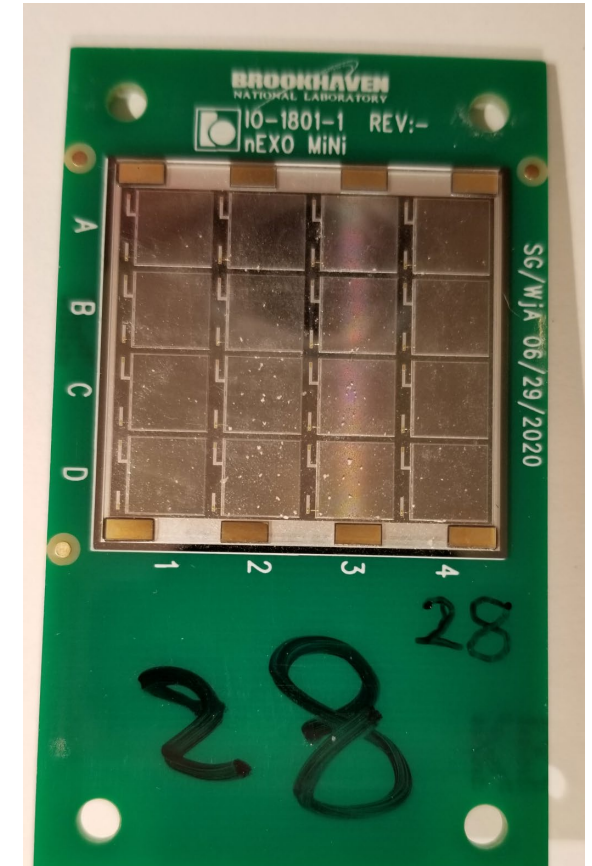
4.7 mV/fC

2 MHz ADC (0.5 μ s/bin)

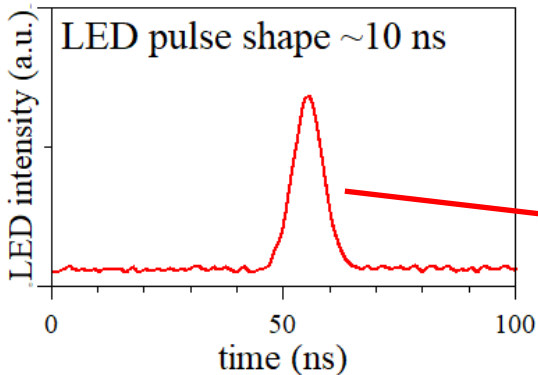
10 MHz ref. clock lock



Data streaming mode
Data collection: LabView
Data analysis: Python

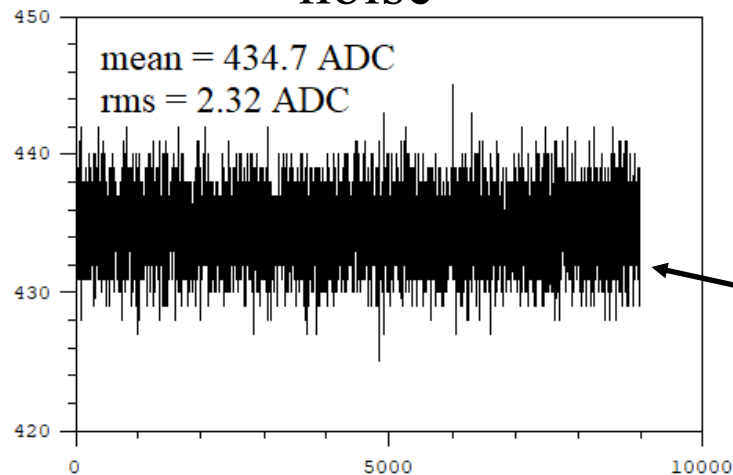


Photon flash rate 100 Hz

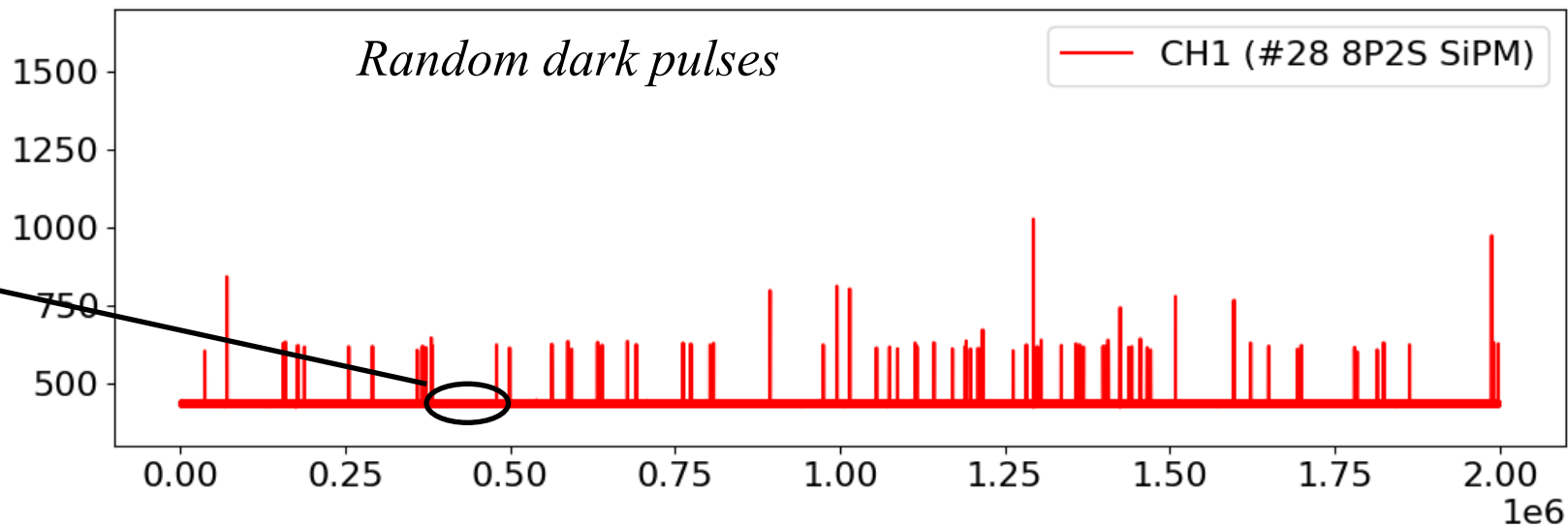


Minitile #28 8P2S in LN₂ @ 4.2 V : subset of raw signal trace (1 second)

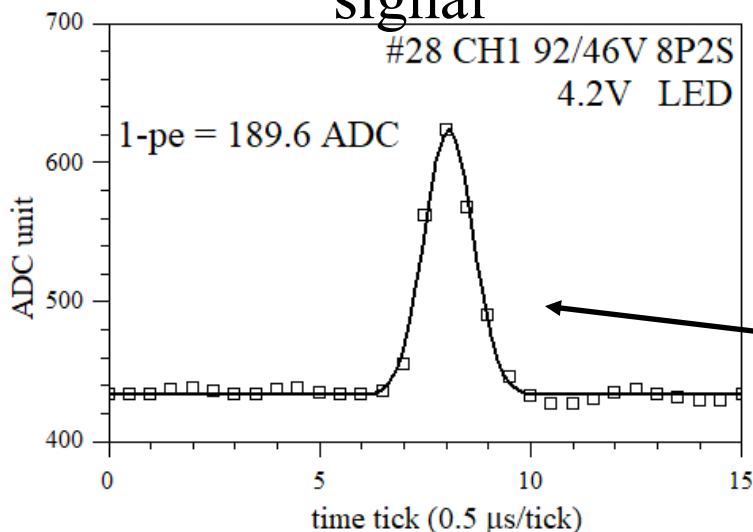
noise



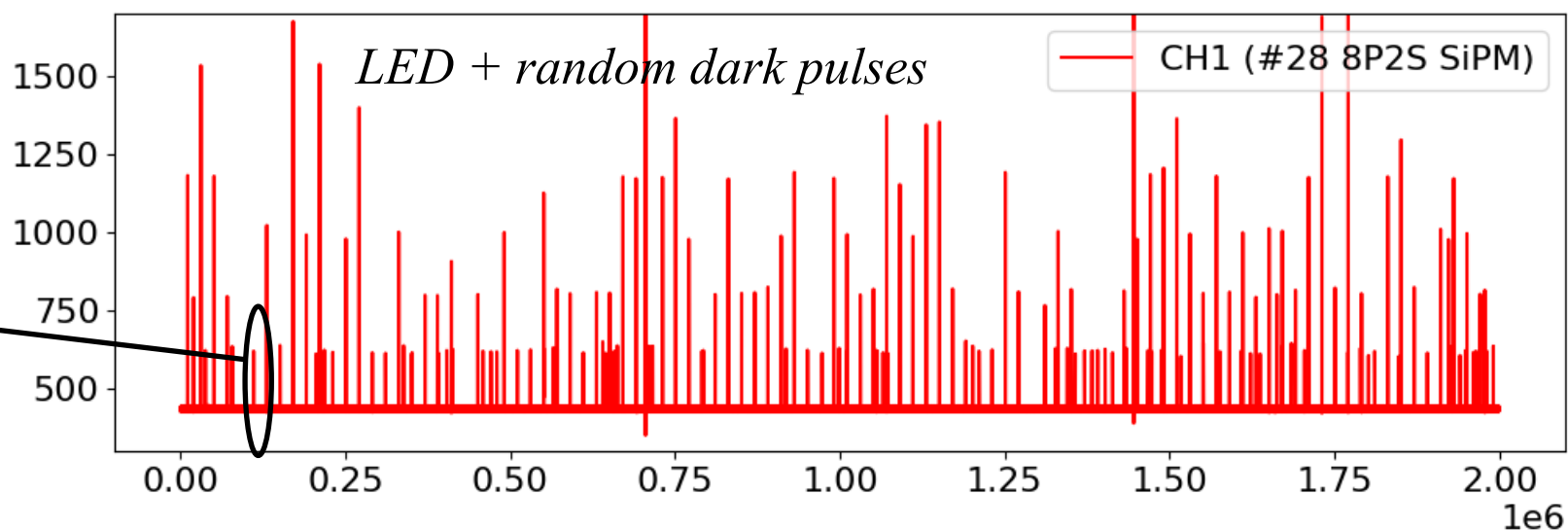
Random dark pulses



signal



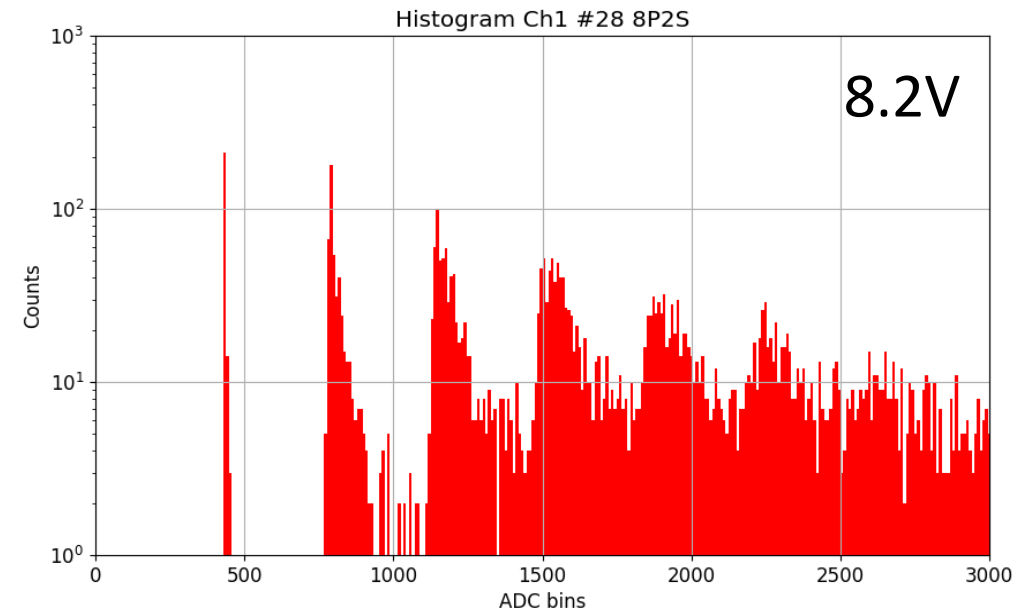
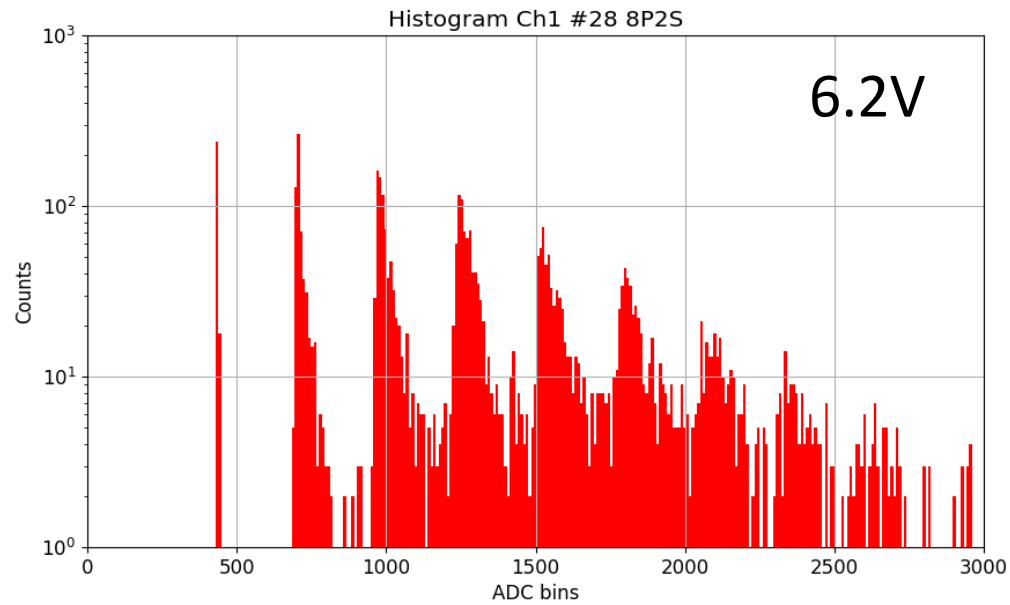
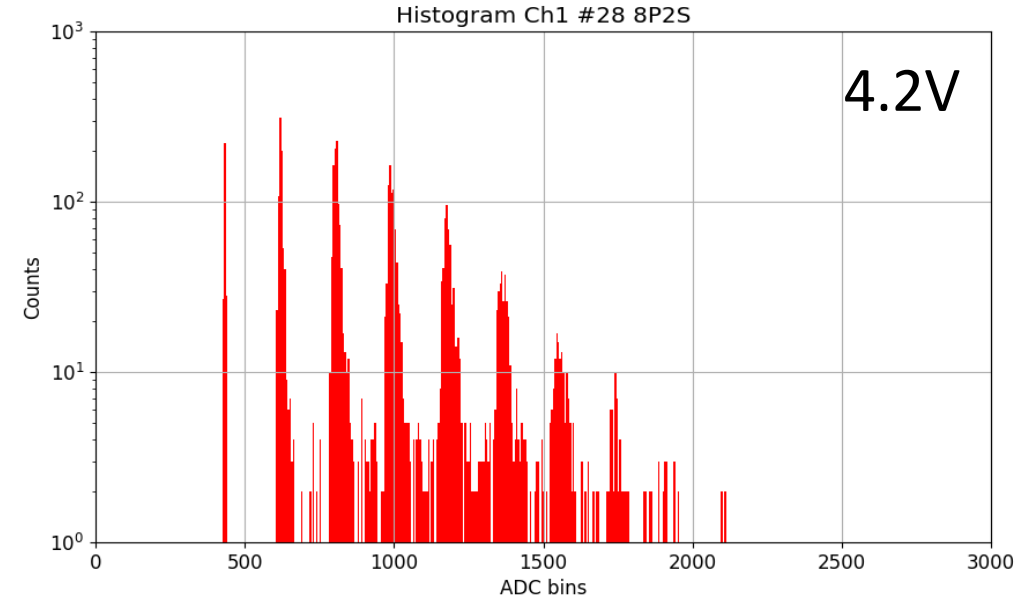
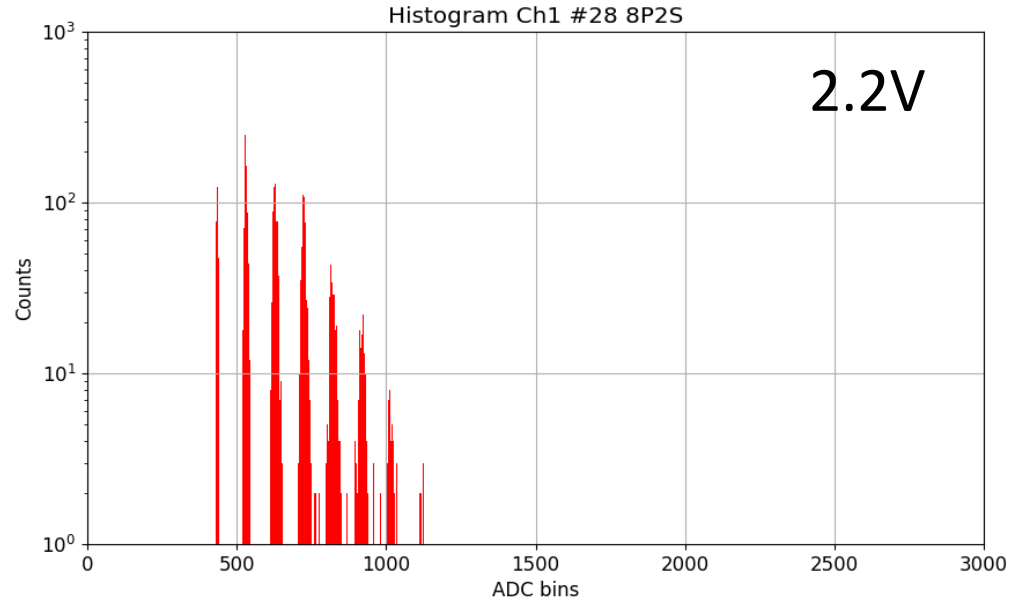
LED + random dark pulses



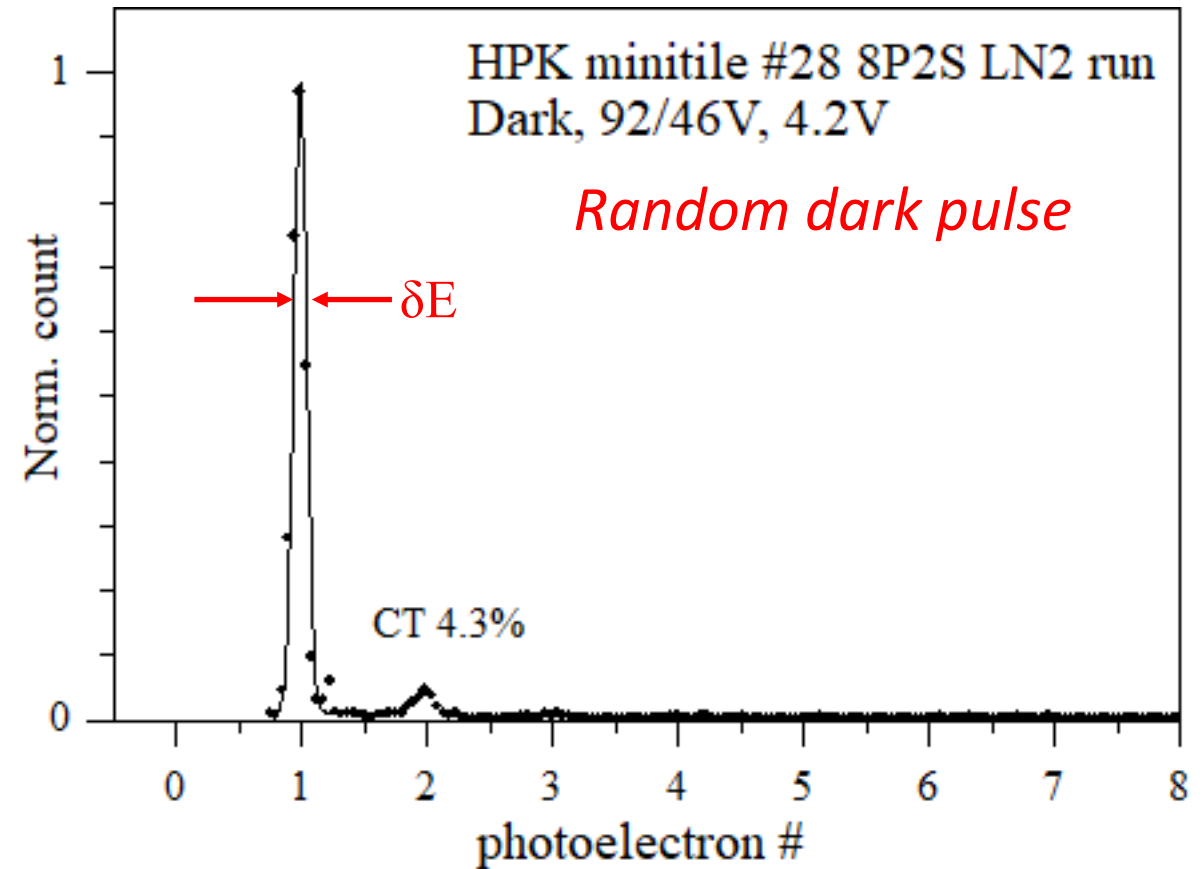
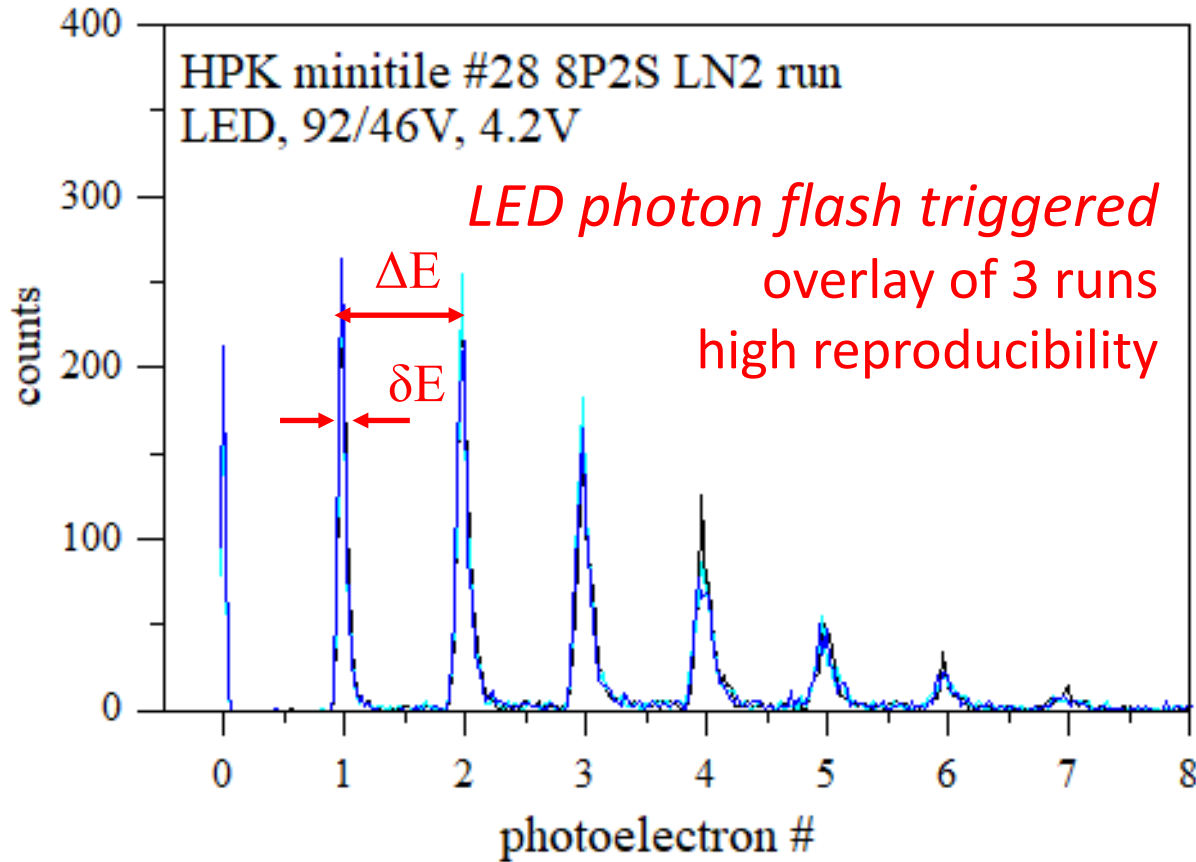
Time tick [0.5 μ s/tick] total of 1 second

$$S/N = 189.6/2.32 = 81.7$$

Minitile #28 8P2S: Charge Histogram, LN₂



Minitile #28 8P2S: Charge Histogram, LN₂



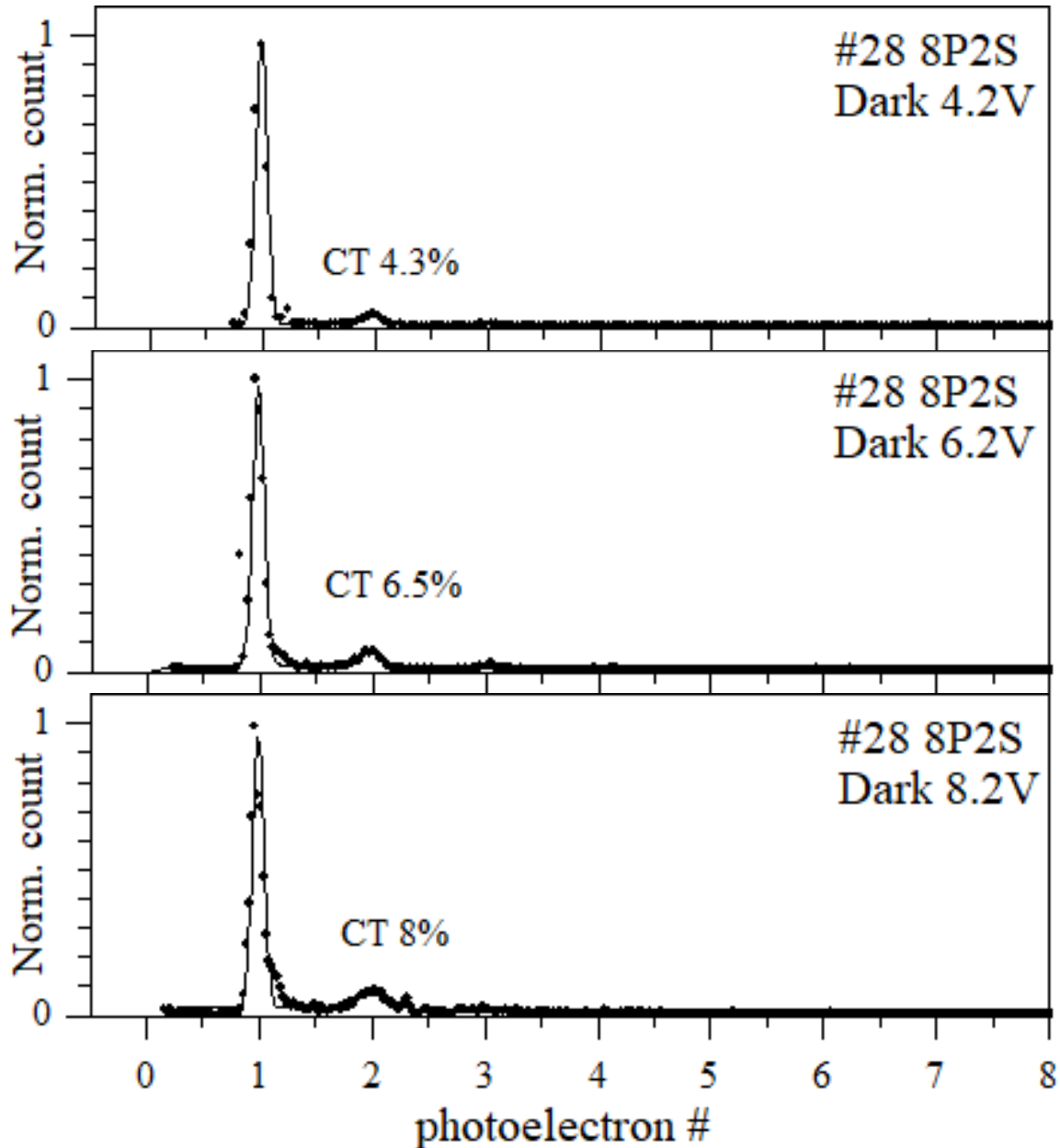
Photon rate: ~80 Hz (trigger rate 100 Hz)

1-pe resolution ($\frac{\delta E}{\Delta E}$): 3 to 3.5% rms

DCR: ~96 Hz (0.17 Hz/mm²)

1-pe resolution (δE): ~5% rms

Minitile #28 8P2S in LN2 random dark pulse Charge Histogram



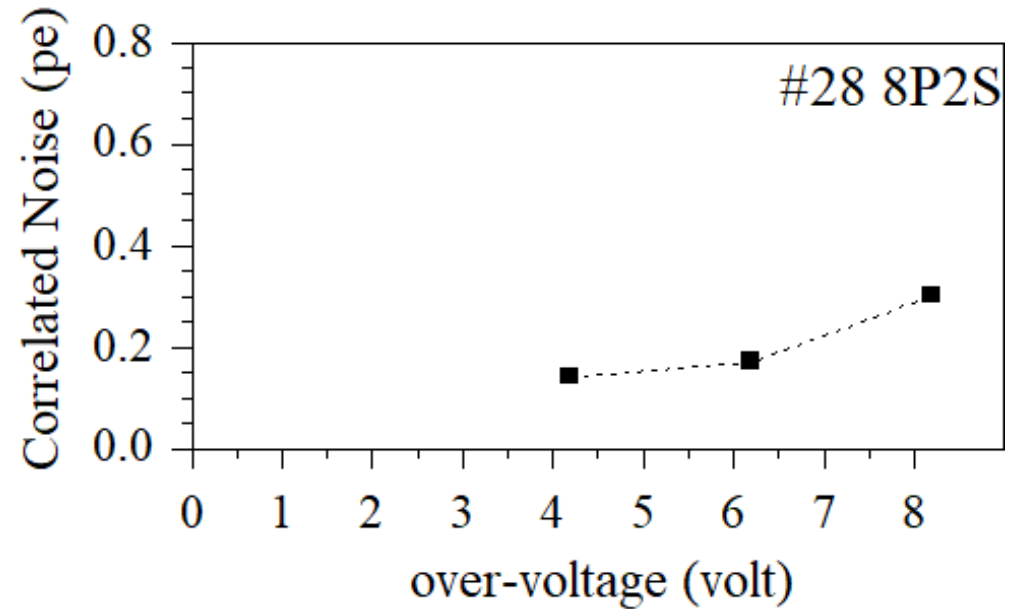
$$\text{Correlated Noise (pe)} = N_{\text{APA}} = \frac{1}{N} \sum_{i=1}^N \frac{A_i}{\bar{A}_{1\text{-PE}}} - 1$$

A_i = charge of prompt pulse i

$\bar{A}_{1\text{-PE}}$ = average charge of 1-pe pulse

N = number of prompt avalanches analyzed

G. Gallina, et al., *Characterization of the Hamamatsu VUV4 MPPCs for nEXO*, NIM A940, 371 (2019).



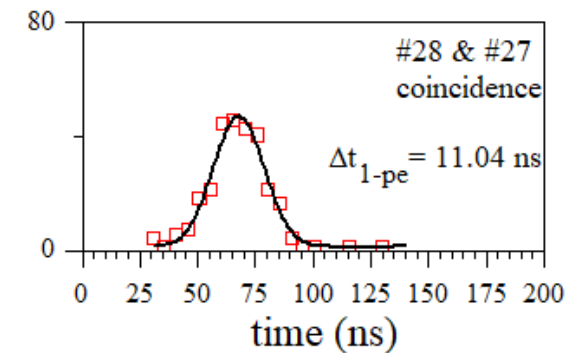
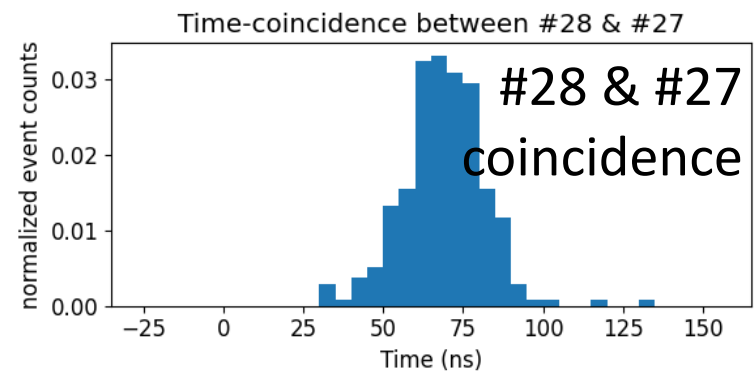
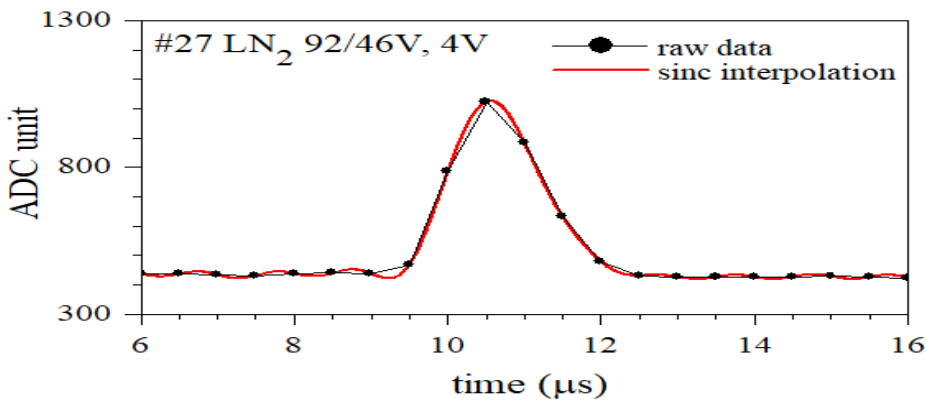
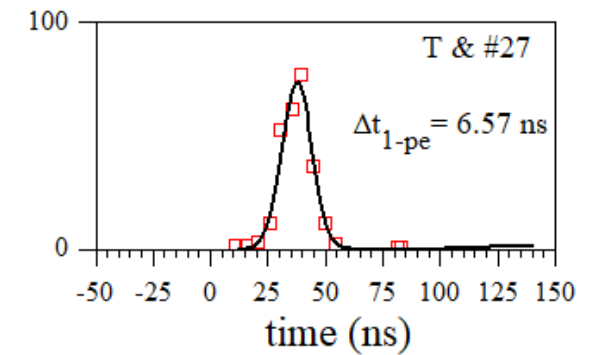
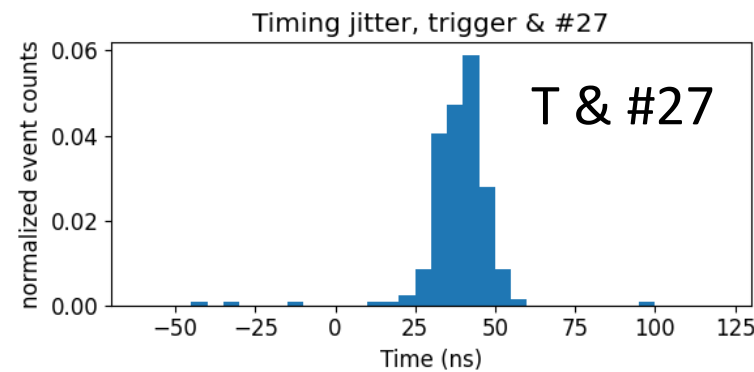
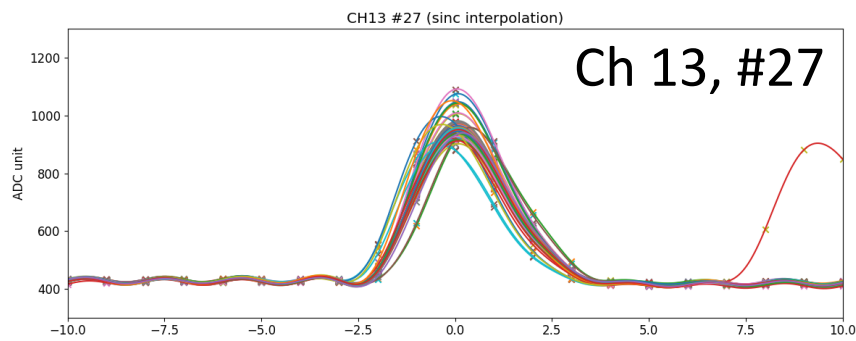
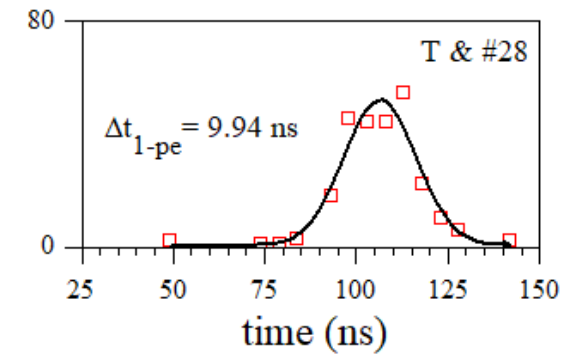
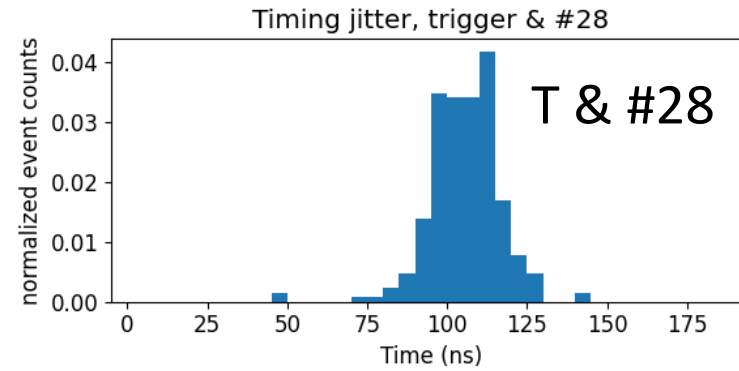
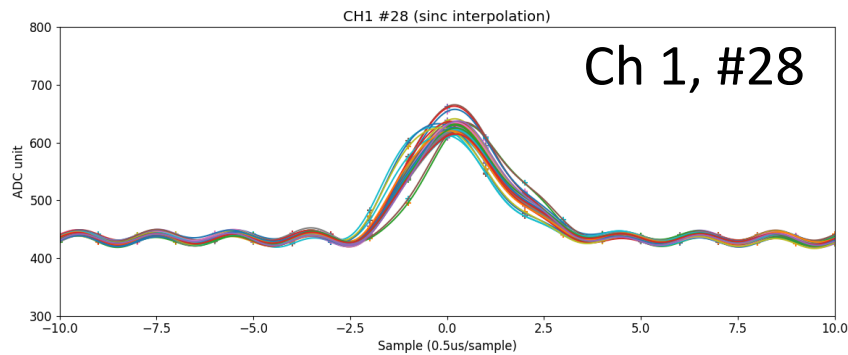
Correlated Noise (@ 4V) ~ 0.12 pe

waveform reconstruction and 1-pe timing resolution, 10 MHz lock ON

Select ONLY 1-pe pulses

1-pe time jitter histogram, 45 sec data

Gaussian fit of histogram



sinc-interpolation + peak finding led to good timing analysis